



**The Abdus Salam  
International Centre for Theoretical Physics**



**2145-16**

**Spring College on Computational Nanoscience**

*17 - 28 May 2010*

**From Supported Clusters to Nanocatalysis  
Part III**

Gianfranco PACCHIONI  
*Dipt. Scienze dei Materiali  
Univ. Milano Bicocca  
Italy*

Spring College on Computational Nanoscience, Trieste, May 21, 2010

## FROM SUPPORTED CLUSTERS TO NANOCATALYSIS

### New phenomena: metal clusters on ultra-thin oxide films



Gianfranco Pacchioni  
*Dipartimento di Scienza dei Materiali*  
*Università Milano-Bicocca*

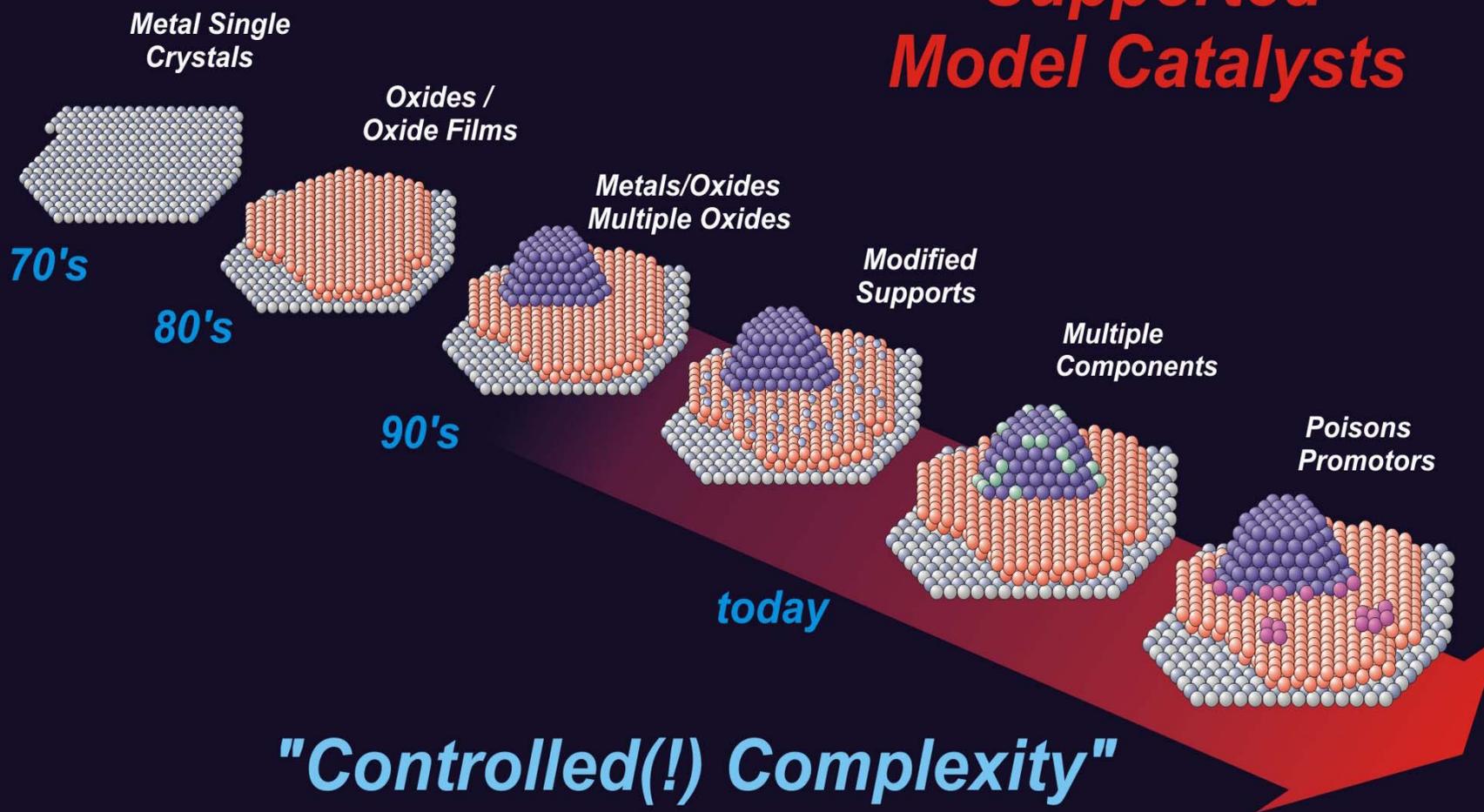


Part I – Nanocatalysis: supported clusters, particles, and model systems

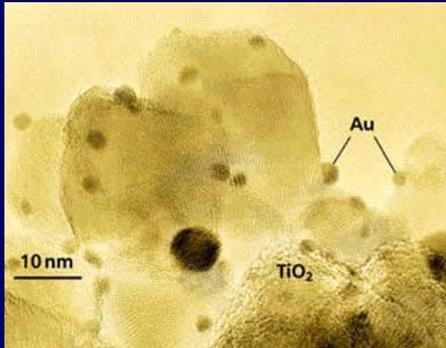
Part II - CO on MgO: lessons from 25 years of interplay between theory and experiment

**Part III – New phenomena: metal clusters on ultra-thin oxide films**

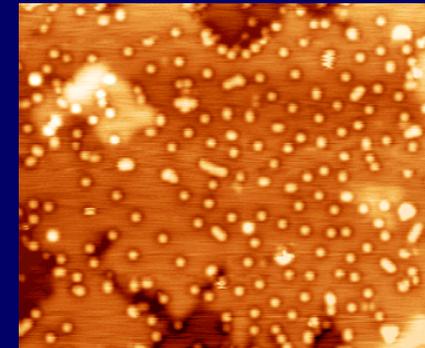
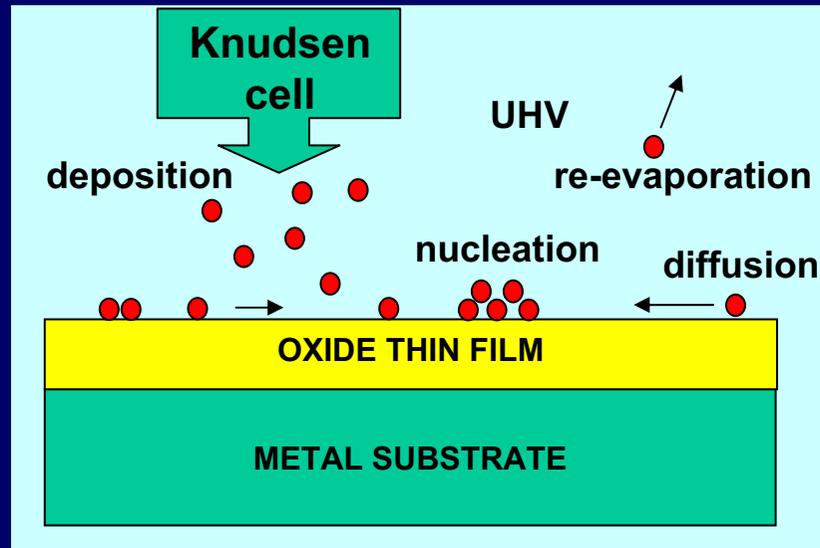
# Supported Model Catalysts



# METAL CLUSTERS ON OXIDE SURFACES AND THIN FILMS



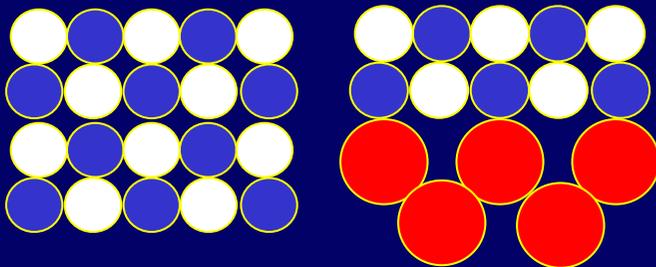
**Real system: Au nanocatalyst on TiO<sub>2</sub>**



**Model system: Au nanoclusters on MgO/Ag(100)**

thin oxide films (<10 layers) grown on a metal substrate in UHV allow use of STM, electron spectroscopies, etc. Full characterization of oxide substrate

Clusters produced from metal vapor deposition (self-assembling)



Bulk oxides versus thin films: same behavior?  
Strain in epitaxial films - Oscillation of properties with number of layers - Bonding at metal-oxide interface, etc.

# ATOMS AND NANOPARTICLES ON OXIDE ULTRA-THIN FILMS (<1 nm)

## Supercell calculations

Plane wave basis set

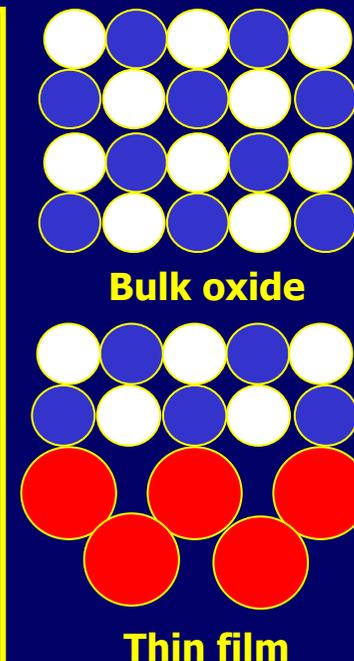
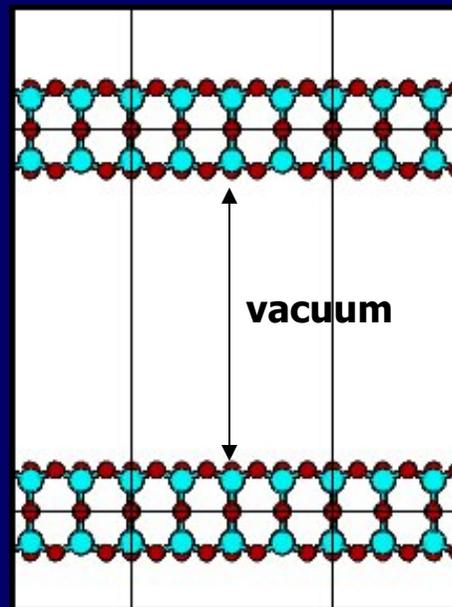
Pseudopotentials + Projector Augmented Wave (PAW, Blöchl)

Perdew-Wang GGA exchange-correlation functional (PW91)

1-5 oxide layers, >10 Å vacuum

large unit cells,  $\approx 100$  atoms/cell

VASP (G. Kresse, Vienna)



HJ Freund



M Heyde



N Nilus



T Risse



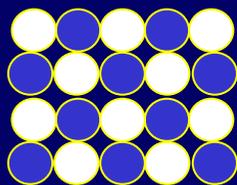
M Sterrer



Shaikutdinov

Fritz-Haber Institut der Max Planck Gesellschaft, Berlin

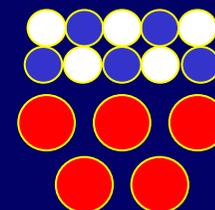
## Pd atoms adsorbed on MgO and MgO/Mo(100)



**Pd/MgO(100)**

|           | on-top O    |             | on-top Mg   |             |
|-----------|-------------|-------------|-------------|-------------|
|           | E(eV)       | r, Å        | E(eV)       | r, Å        |
| <b>1L</b> | <b>1.87</b> | <b>2.03</b> | <b>0.68</b> | <b>2.49</b> |
| <b>2L</b> | <b>1.50</b> | <b>2.05</b> | <b>0.58</b> | <b>2.54</b> |
| <b>3L</b> | <b>1.53</b> | <b>2.05</b> | <b>0.58</b> | <b>2.54</b> |
| <b>4L</b> | <b>1.52</b> | <b>2.05</b> | <b>0.58</b> | <b>2.54</b> |

- **Unsupported MgO films – results converged after three layers (3L)**
- **Adsorption on O preferred over adsorption on Mg by a factor 3**



**Pd/MgO/Mo(100)**

|           | on-top O    |             | on-top Mg   |             |
|-----------|-------------|-------------|-------------|-------------|
|           | E(eV)       | r, Å        | E(eV)       | r, Å        |
| <b>1L</b> | <b>1.52</b> | <b>2.15</b> | <b>1.06</b> | <b>2.49</b> |
| <b>2L</b> | <b>1.69</b> | <b>2.11</b> | <b>0.99</b> | <b>2.55</b> |
| <b>3L</b> | <b>1.55</b> | <b>2.07</b> | <b>0.80</b> | <b>2.57</b> |
| <b>4L</b> | <b>1.54</b> | <b>2.07</b> | <b>0.73</b> | <b>2.57</b> |

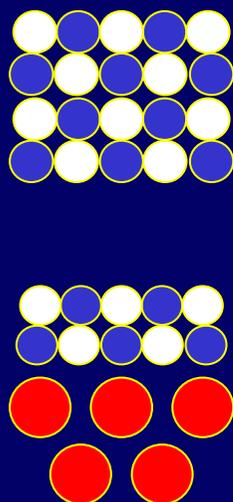
- **Supported MgO films on Mo(100) - results converged after 4L**
- **MgO(100) and MgO/Mo(100): similar bonding properties**

## Au atoms adsorbed on MgO and MgO/Mo(100)

| Au/MgO(100) |          |      |           |      |
|-------------|----------|------|-----------|------|
|             | on-top O |      | on-top Mg |      |
|             | E(eV)    | r, Å | E(eV)     | r, Å |
| 1L          | 1.35     | 2.24 | 0.63      | 2.63 |
| 2L          | 0.98     | 2.24 | 0.48      | 2.69 |
| 3L          | 1.01     | 2.24 | 0.49      | 2.70 |
| 4L          | 1.01     | 2.24 | 0.49      | 2.70 |

| Au/MgO/Mo(100) |          |      |           |      |
|----------------|----------|------|-----------|------|
|                | on-top O |      | on-top Mg |      |
|                | E(eV)    | r, Å | E(eV)     | r, Å |
| 1L             | 2.00     | 2.68 | 2.27      | 2.55 |
| 2L             | 2.06     | 2.76 | 2.21      | 2.58 |
| 3L             | 1.64     | 2.76 | 1.87      | 2.57 |
| 4L             | 1.42     | 2.70 | 1.61      | 2.61 |
| 5L             | 1.29     | 2.63 | 1.44      | 2.64 |

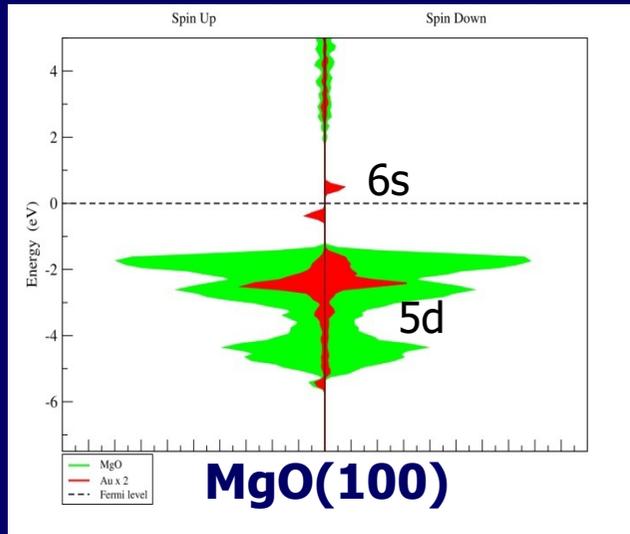
- Unsupported MgO films – results converged after three layers (3L)
- Adsorption on O preferred over Mg
- Au-MgO bonding weaker than Pd-MgO



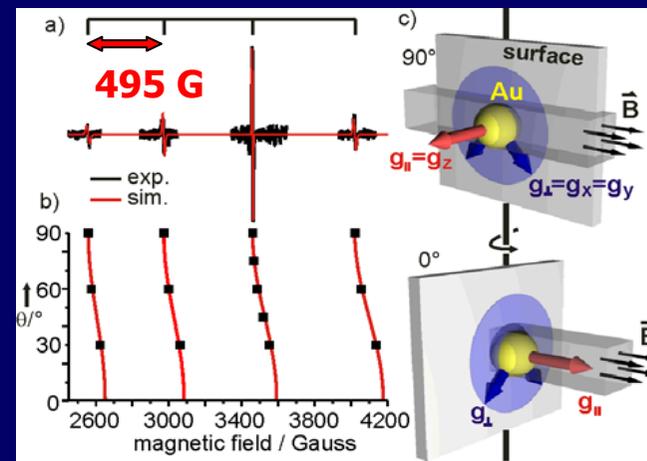
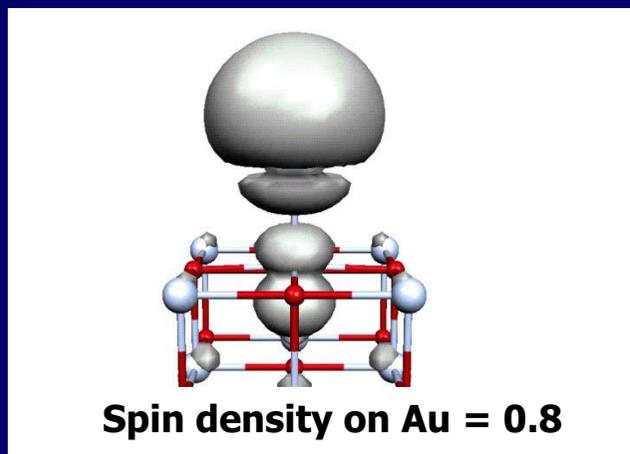
- Supported MgO films - even after 5L of MgO on Mo(100) results not fully converged
- Adsorption on Mg preferred over adsorption on O !
- Adsorption on MgO/Mo very different from MgO(100)

**WHY IS Au DIFFERENT FROM Pd?**

# Au ATOM ON BULK MgO(100) SURFACE



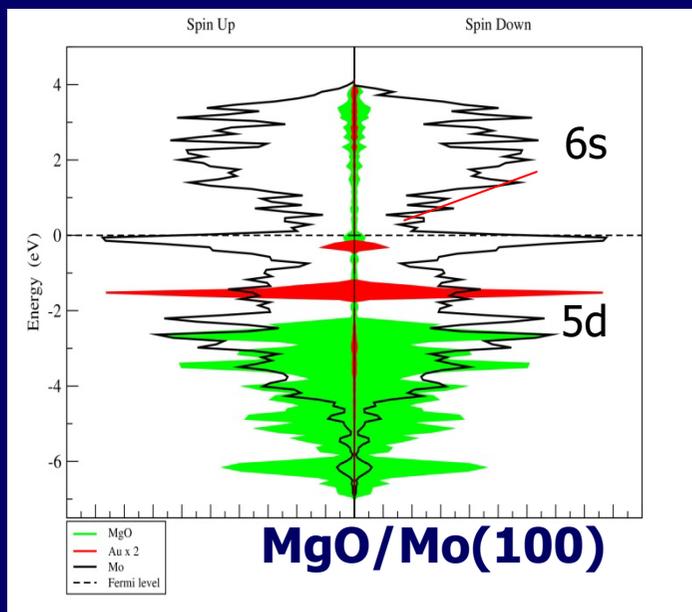
- **Au 6s level:  $\alpha$  component filled,  $\beta$  component empty**
- **Au  $(6s)^1$  is paramagnetic**
- **Proven by Electron Paramagnetic Resonance (EPR)**



On bulk MgO the Au atom is neutral

Yulikov, Sterrer, Heyde, Rust, Risse, Freund, GP, Scagnelli,  
PRL 96, 146804 (2006)

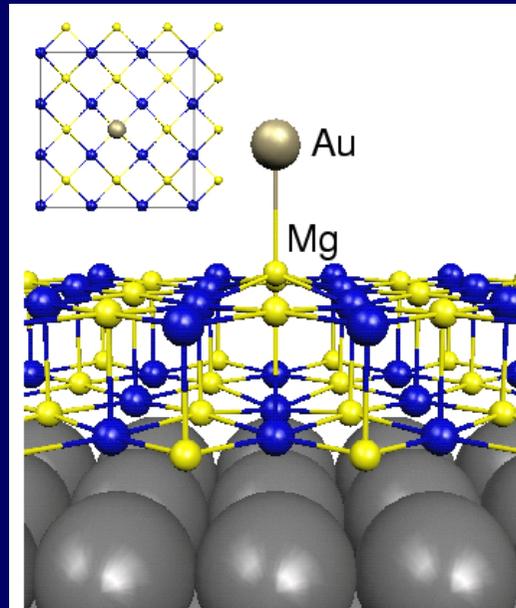
## Au ATOM ON Au/MgO/Mo(100) FILMS



Au/MgO/metal

■ Au 6s level is below  $E_F$  (Mo)

■ Net charge transfer makes Au negatively charged,  $Au^-$

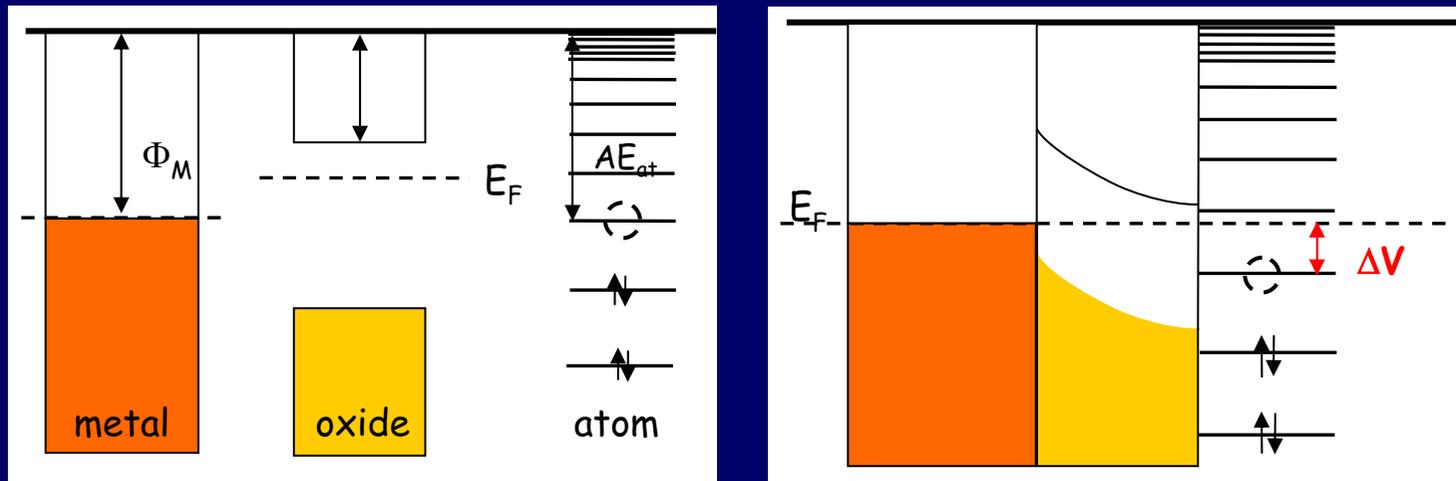


MgO/Mo(100) or MgO/Ag(100): Au is a full anion  
Different behavior of Pd atom (always neutral)

GP, Giordano, Baistrocchi, Phys. Rev. Lett. 94, 226104 (2005)

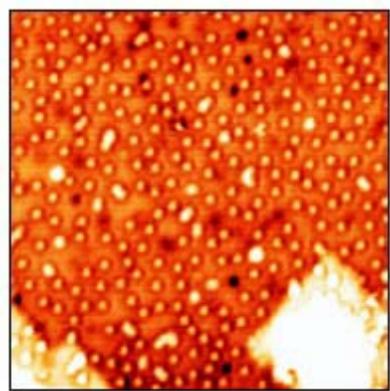
Giordano, GP, Phys. Chem. Chem. Phys. 8, 3335 (2006)

## CHARGING OF ADSORBATES ON OXIDE THIN FILMS

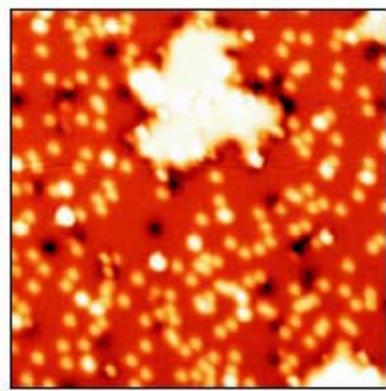


- metal clusters, molecules or defects on MgO/metal thin films: empty levels may fall below (above) metal  $E_F$
- charge flow through a dielectric barrier not possible for thick insulating films but possible by direct tunneling in ultrathin films ( $< 1$  nm)

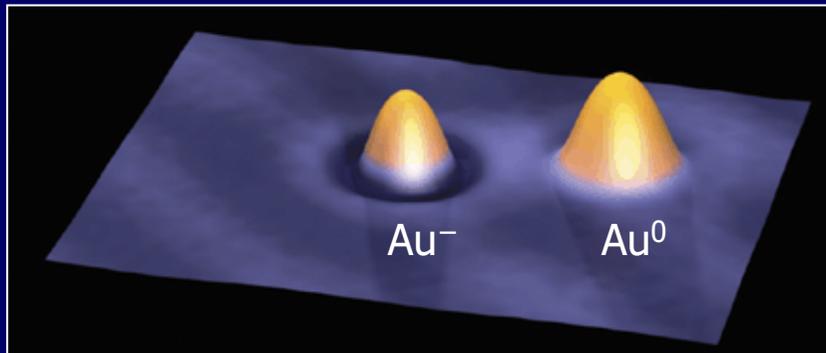
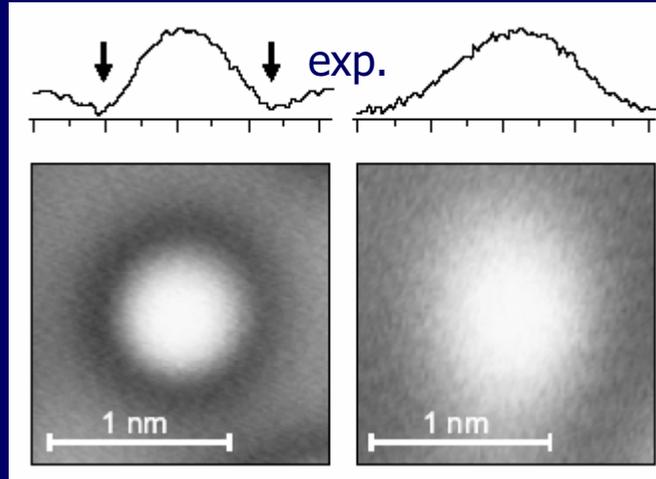
# Au/MgO(3L)/Ag(100): charging proven by STM



Au/MgO(3L)/Ag(100)

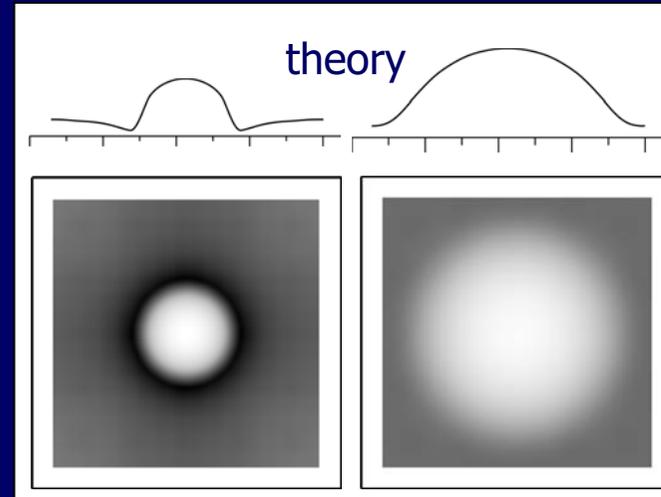


Pd/MgO(3L)/Ag(100)



Au atoms on NaCl/Cu(111). Au<sup>-</sup> shows typical "sombbrero" shape (charged state)

Repp et al. *Science* **305**, 493, (2004)

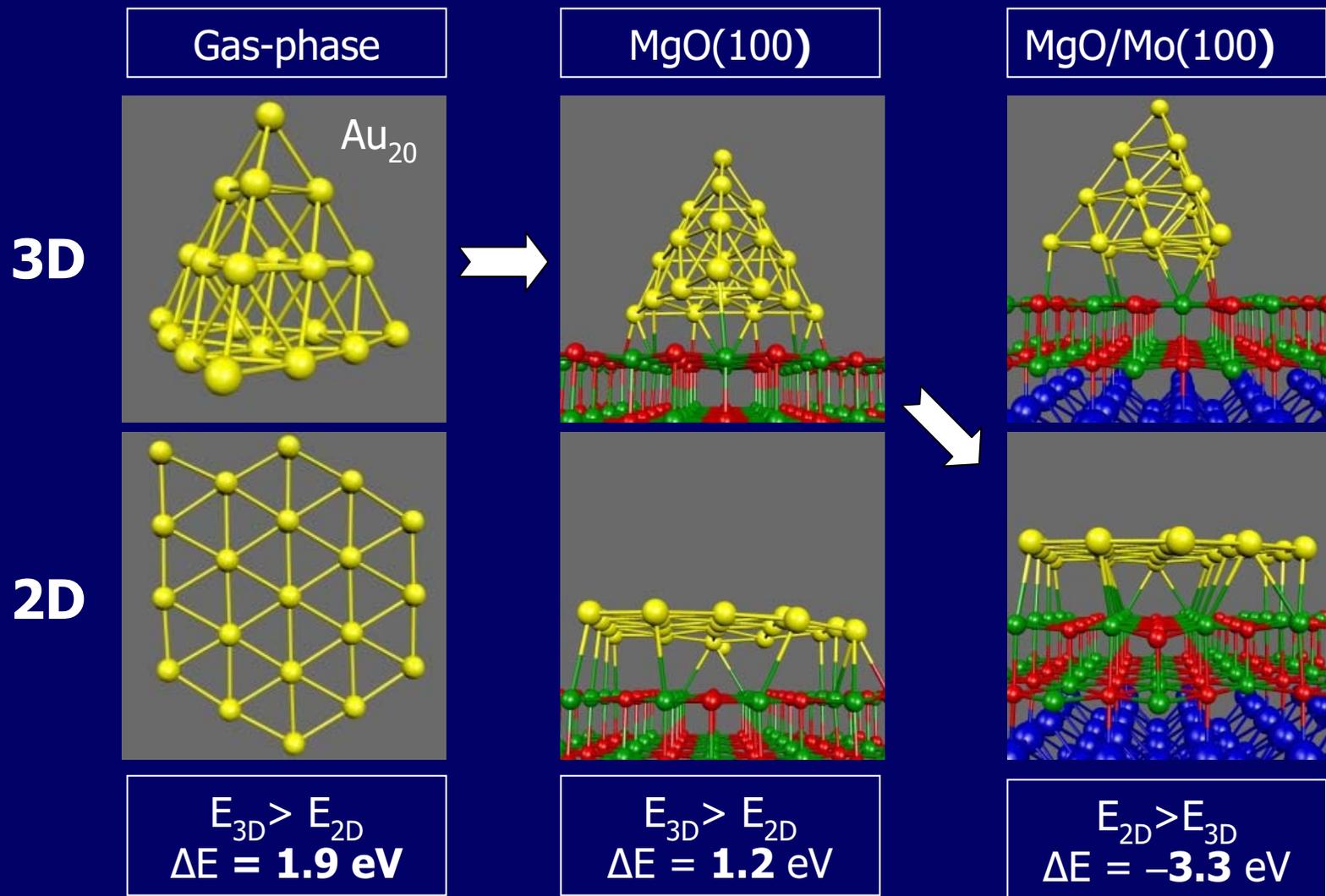


Au atom

Pd atom

**Sterrerr, Risse, Martinez, Giordano, Heyde, Rust, GP, Freund,**  
**Phys. Rev. Lett. 98, 096107 (2007)**

**Au<sub>n</sub> clusters: gas-phase ⇒ MgO(100) ⇒ MgO/Mo(100)**



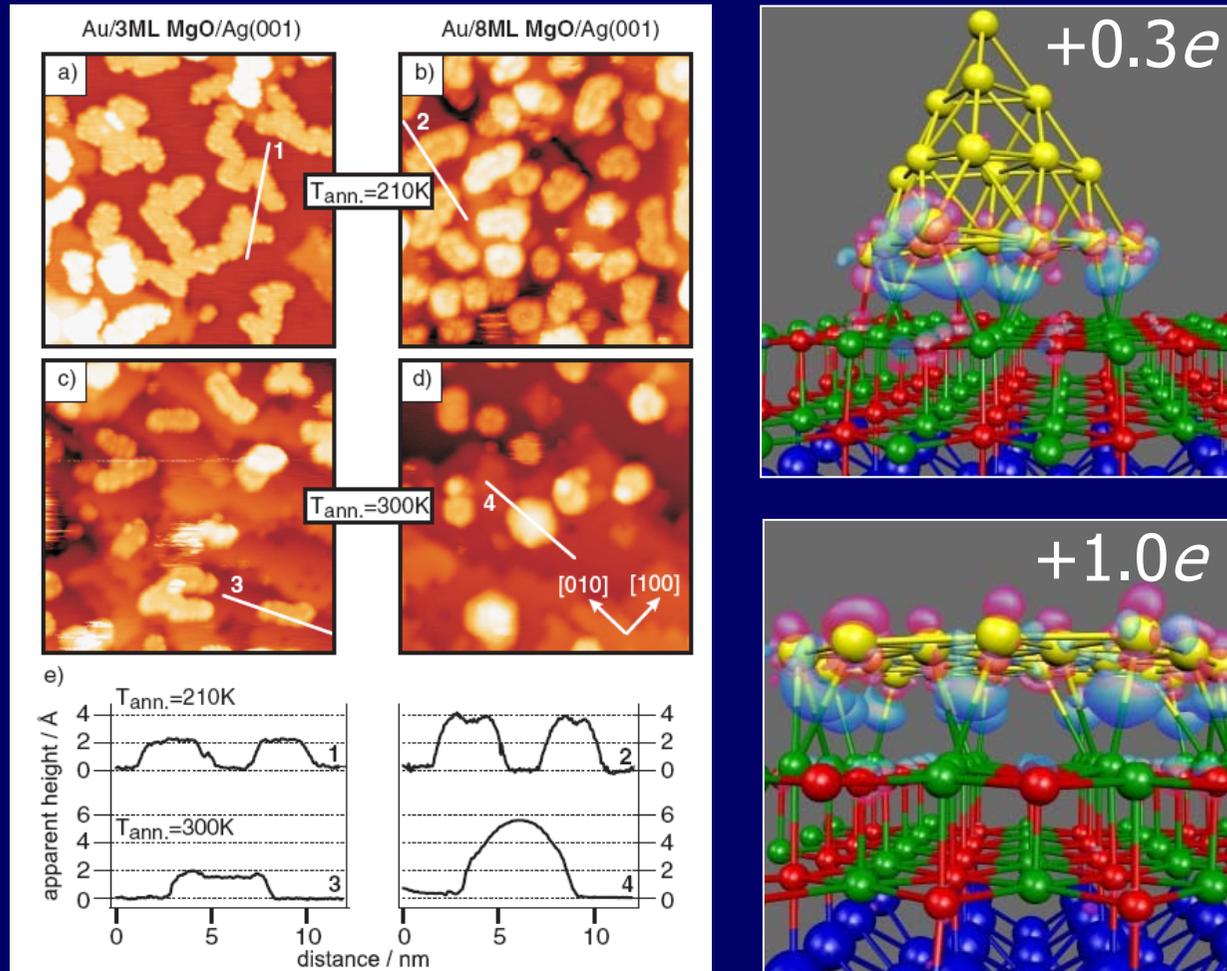
**Ricci, Bongiorno, GP, Landman, Phys. Rev. Lett. 97, 036106 (2006)**

## Crossover from Three-Dimensional to Two-Dimensional Geometries of Au Nanostructures on Thin MgO(001) Films: A Confirmation of Theoretical Predictions

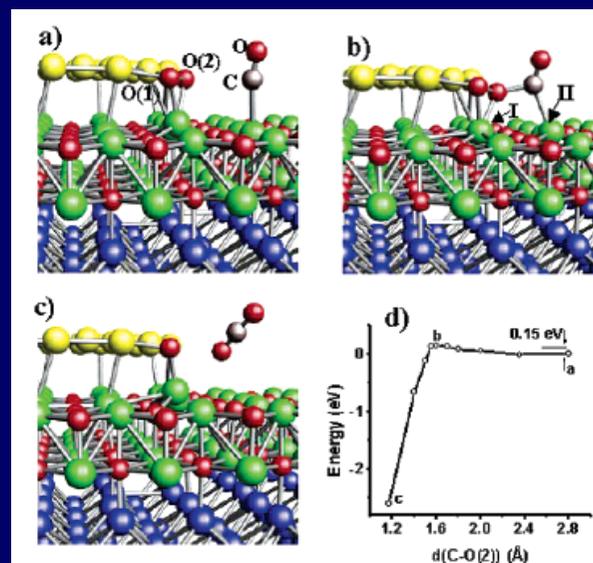
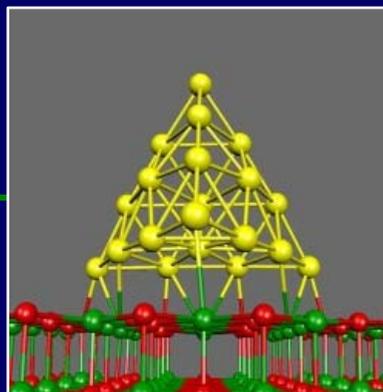
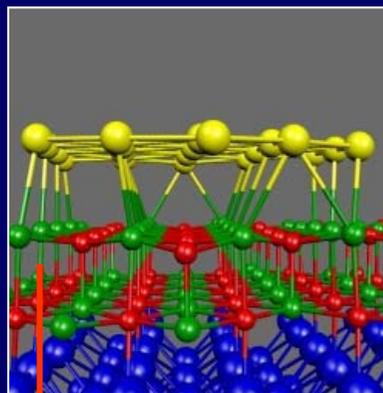
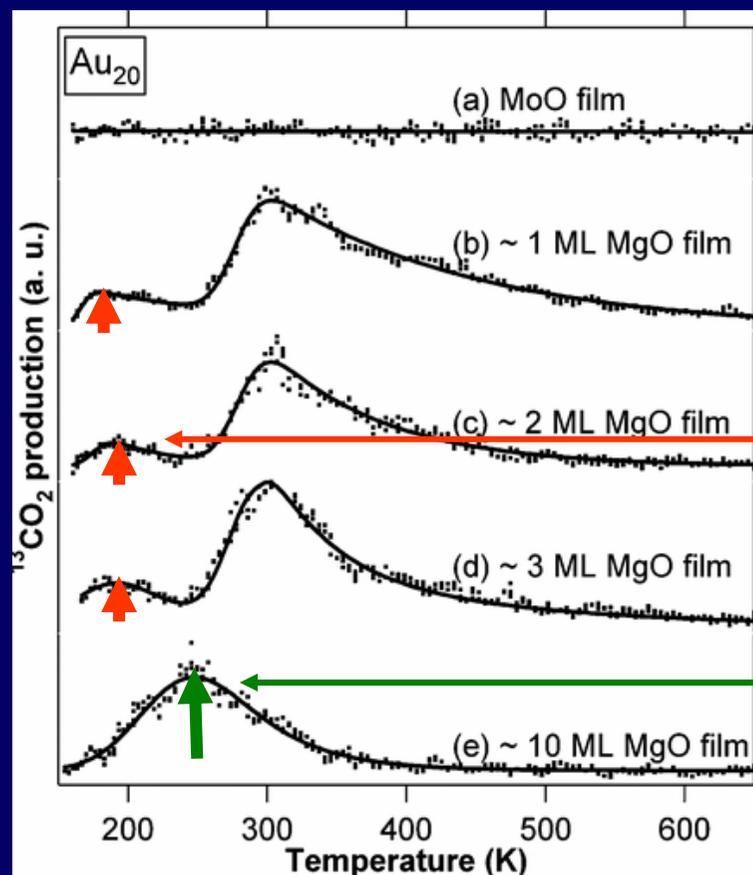
Martin Sterrer,\* Thomas Risse, Markus Heyde, Hans-Peter Rust, and Hans-Joachim Freund

*Fritz-Haber-Institut der Max-Planck-Gesellschaft, Department of Chemical Physics, Faradayweg 4-6, D-14195 Berlin, Germany*

(Received 1 February 2007; published 14 May 2007)



# NANOCATALYSIS: Au ON MgO/Mo FILMS



**Au<sub>20</sub>/MgO/Mo: Au<sub>20</sub> 2D more active than 3D in CO oxidation (DFT)**

Zhang, Yoon, Landman J. Am. Chem. Soc. 129, 2228, 2007

- Au clusters on thick (10ML) and thin (1-3 ML) MgO/Mo films: different activity in CO oxidation
- Thin films: CO<sub>2</sub> forms at 180 K; thick films: CO<sub>2</sub> forms at 250 K (TPD)
- Different reaction mechanism

Harding, Habibpour, Kunz, Farnbacher, Heiz, Yoon, Landman J. Am. Chem. Soc. 131, 538, 2009

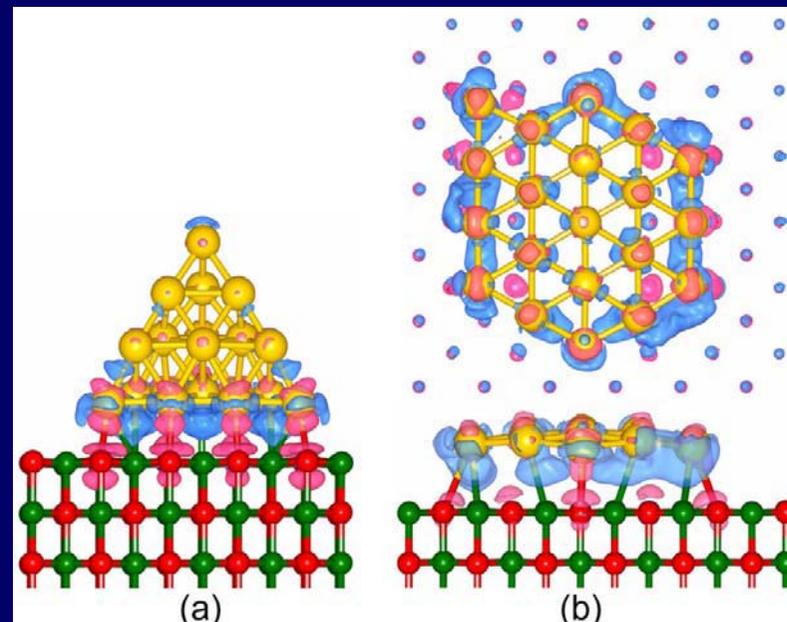
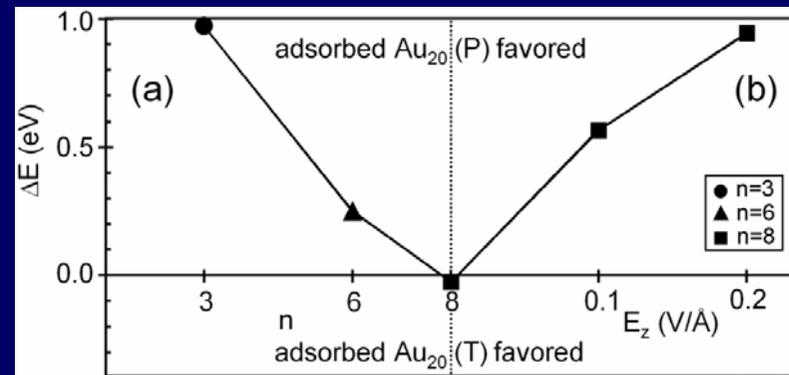
# ELECTRIC FIELD EFFECT ON THE SHAPE OF GOLD NANOPARTICLES ON MgO/Ag(100) FILMS

■ **MgO(8 layers) / Ag(100): Au<sub>20</sub> 3D (tetrahedral) is preferred (as for bulk MgO)**

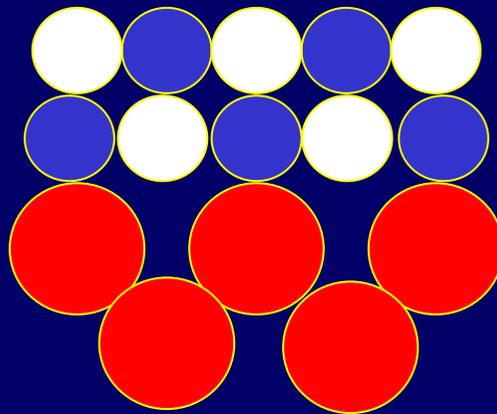
■ **Apply an electric field of 1 V/nm: Au<sub>20</sub> 2D (planar) becomes more stable**

■ **Reason: electric field moves charge from the Ag support to the interface resulting in stronger adhesion of 2D structure**

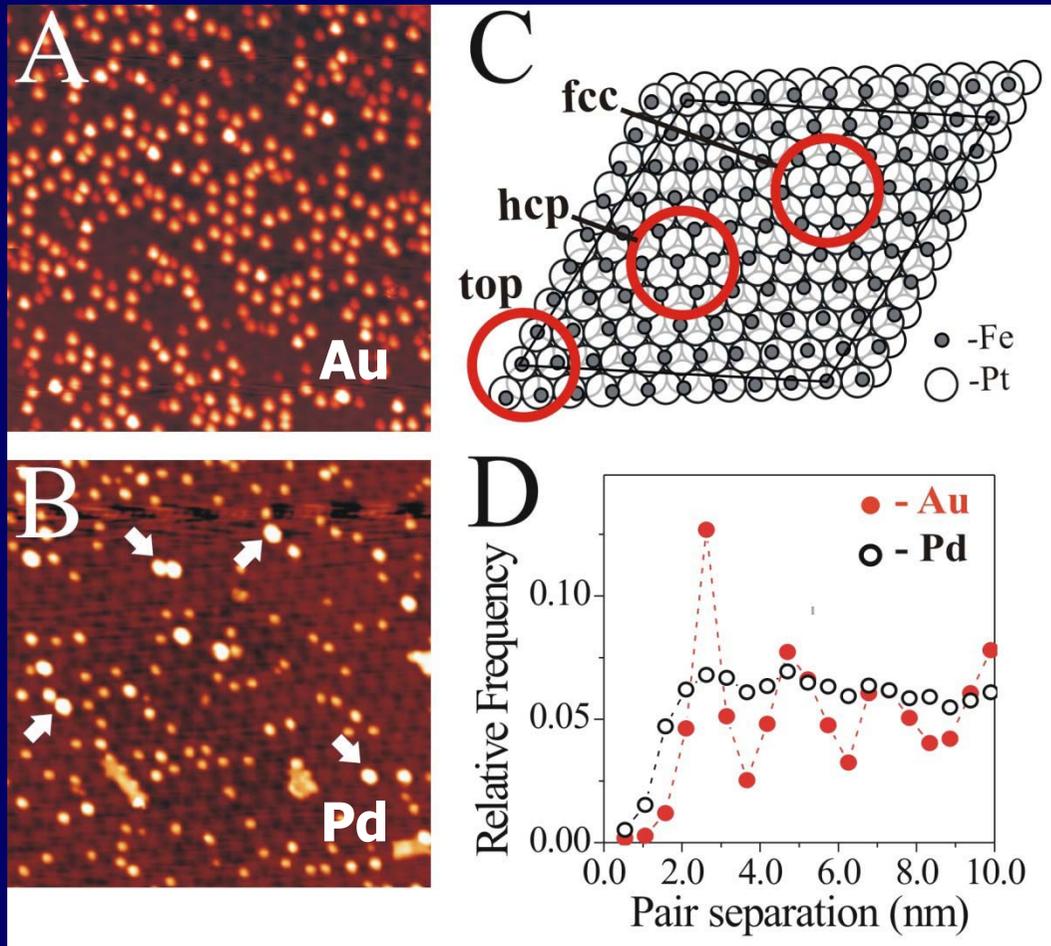
Yoon and Landman, Phys. Rev. Lett. 100, 056102, 2008



IS CHARGING OF METALS ON  
ULTRA-THIN FILMS UNIVERSAL?



## Au AND Pd ATOMS ON FeO/Pt(111)



- FeO/Pt(111): Au atoms deposited at 10K: adsorption on hcp domains
- Self-organization of adsorbed Au atoms
- Not observed for Pd atoms (random distribution)
- Similar as for Au and Pd on MgO/Ag(100)

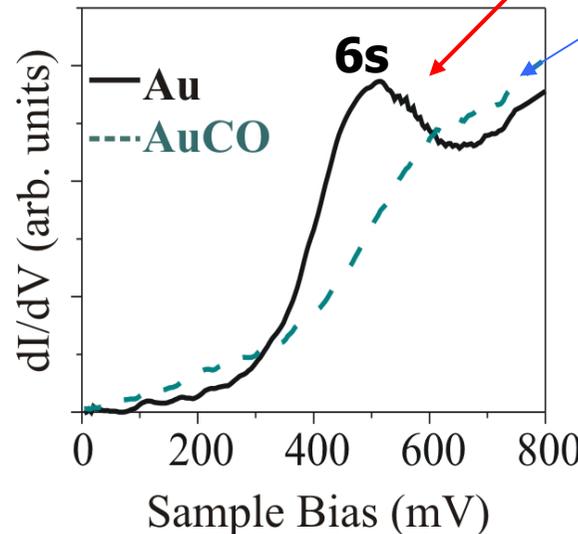
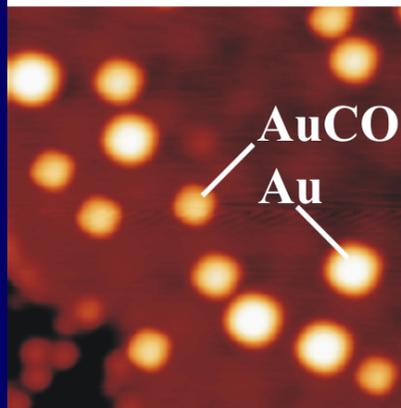
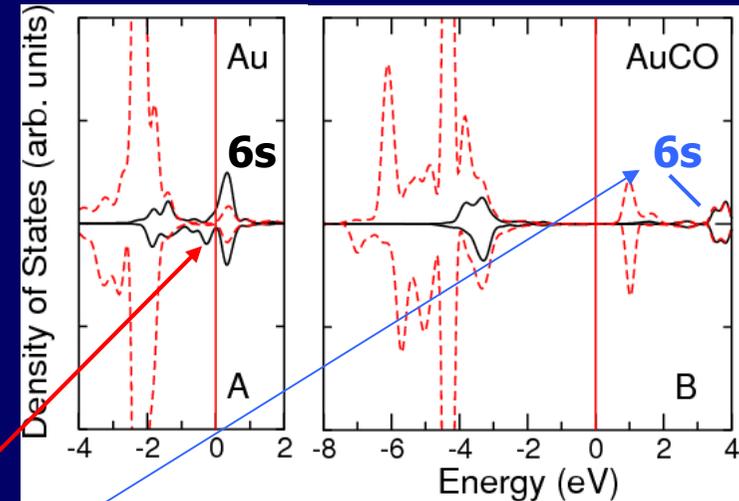
**Are Au atoms negatively charged as on MgO/Ag(100)?**

## Au ATOMS ON FeO/Pt(111)

■ DFT calculations: Au atoms in hcp domains (adsorption on-top of O): 6s level above  $E_F$  (empty)

■ Au is formally  $Au^+$

■ Consistent with  $dI/dV$  curves (empty state on Au 0.5 eV above  $E_F$ )



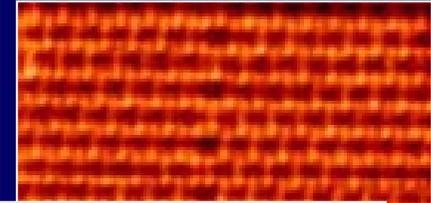
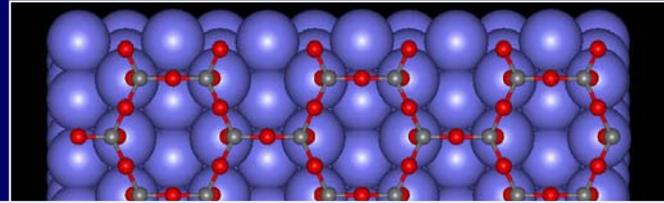
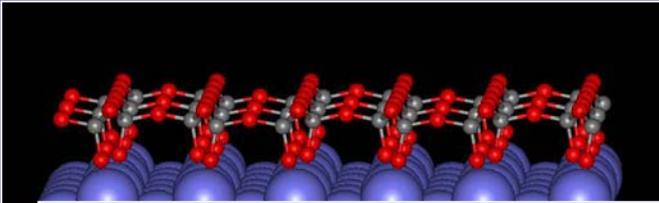
■ Additional proof: CO adsorption shifts empty 6s state to higher energies

■ CO forms strong bond with Au (typical of  $AuCO^+$  complexes)

**Au is positively charged!**

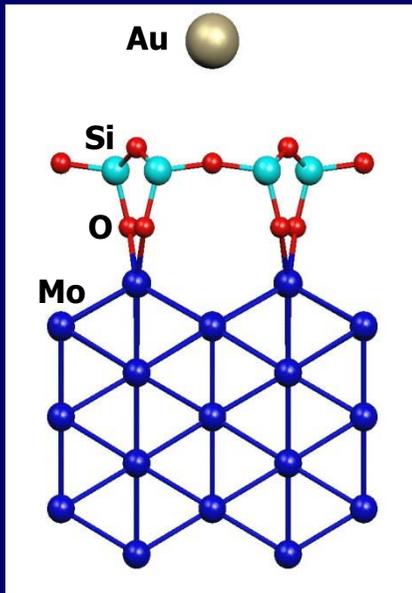
Giordano, GP, Goniakowski, Nilius, Rienks, Freund,  
Phys. Rev. Lett. 101, 026102 (2008)

# Au ATOMS ON SiO<sub>2</sub>/Mo(112)



**Preparation:** Schroeder, Giorgi, Bäumer, Freund, *Phys. Rev. B* 66 (2002) 165422

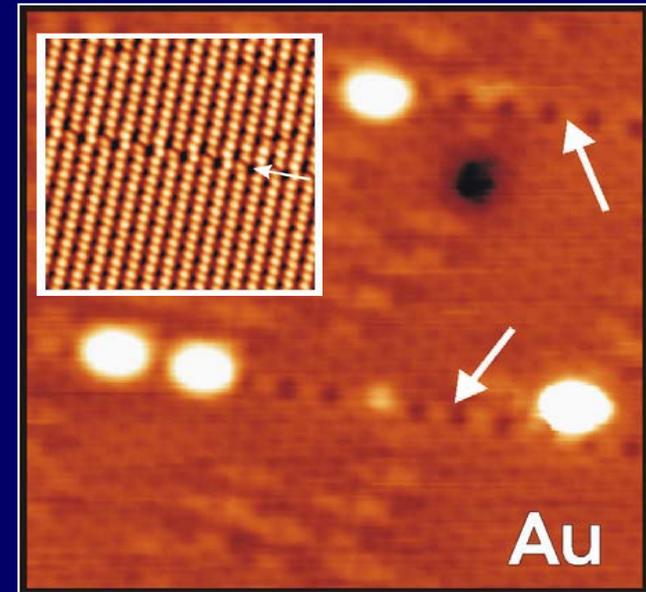
**Structure:** Giordano, Ricci, GP, Ugliengo, *Surf. Sci.* 584 (2005) 225; Weissenrieder, Kaya, Lu, Gao, Shaikhutdinov, Freund, Sierka, Todorova, Sauer, *Phys. Rev. Lett.* 95 (2005) 076103



■ Au atom very weakly adsorbed on all sites ( $D_e < 0.1$  eV)

■ DOS curves show that Au keeps  $6s^1$  configuration

**Au is neutral, NO CHARGE TRANSFER!**



Martinez, Giordano, GP, *J. Phys. Chem. B* 110, 17015 (2006)

## Au ATOMS ON OXIDE THIN FILMS

MgO/Ag(100)

Au is negatively charged, Au<sup>-</sup>

FeO/Pt(111)

Au is positively charged, Au<sup>+</sup>

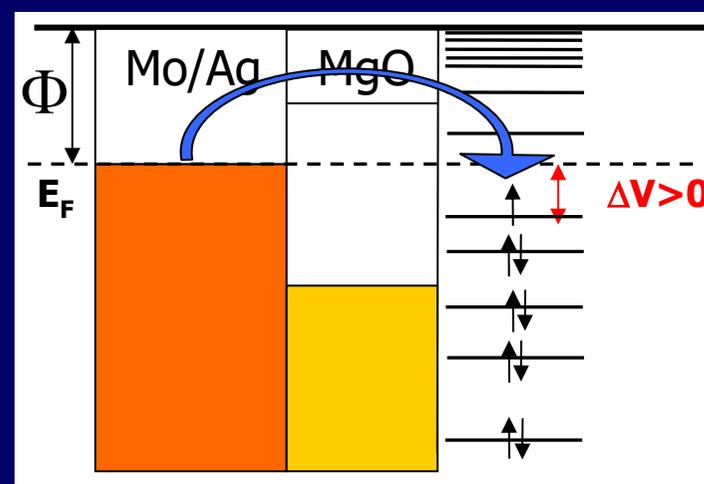
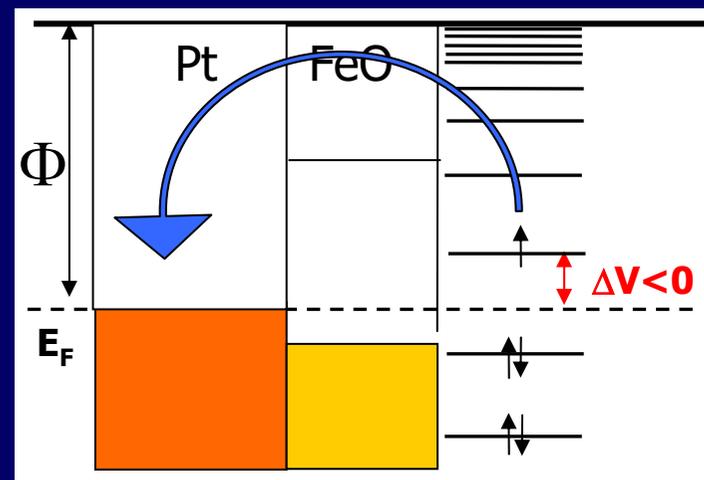
SiO<sub>2</sub>/Mo(112)

Au is neutral, Au<sup>0</sup>

Charge transfer is not universal. Why?

## Oxide films on metal supports: role of work function

| Oxide/Metal                    | $\phi_{O/M}$ eV | $\phi_M$ eV |
|--------------------------------|-----------------|-------------|
| <b>FeO/Pt(111)</b>             | <b>6.0-5.6</b>  | <b>5.8</b>  |
| TiO <sub>2</sub> /Pt(111)      | 5.6             | 5.8         |
| <b>SiO<sub>2</sub>/Mo(112)</b> | <b>4.9</b>      | <b>4.2</b>  |
| TiO <sub>3</sub> /Mo(112)      | 4.6             | 4.2         |
| NiO/Ag(100)                    | 3.9             | 4.3         |
| <b>MgO/Ag(100)</b>             | <b>3.3</b>      | <b>4.3</b>  |
| BaO/Au(100)                    | 2.3             | 5.1         |
| <b>MgO/Mo(100)</b>             | <b>2.1</b>      | <b>4.2</b>  |
| BaO/Ag(100)                    | 2.0             | 4.3         |
| BaO/Pd(100)                    | 2.0             | 5.2         |



FeO/Pt(111) high work function (high electron affinity)  
MgO/Ag(100) low work function (low ionization potential)

# WHAT IS THE ORIGIN OF WORK FUNCTION CHANGES ?

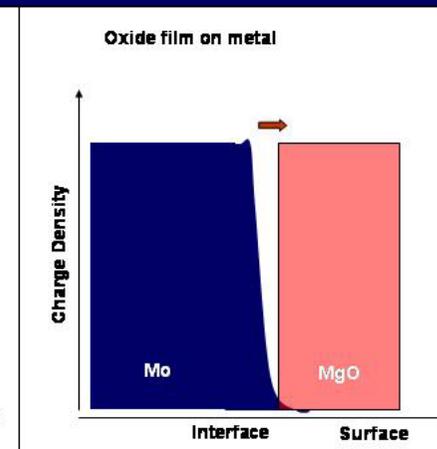
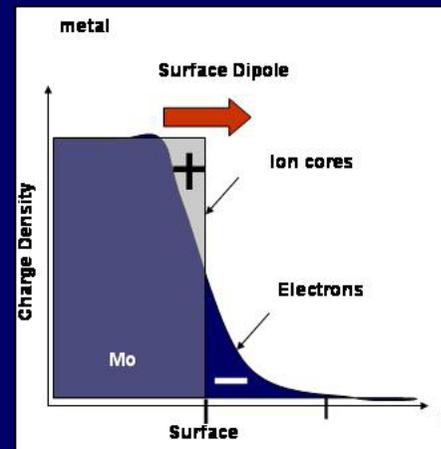
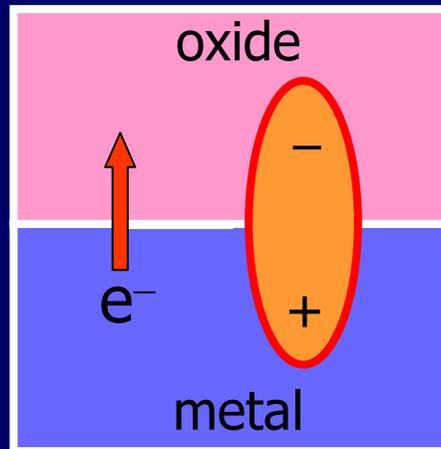
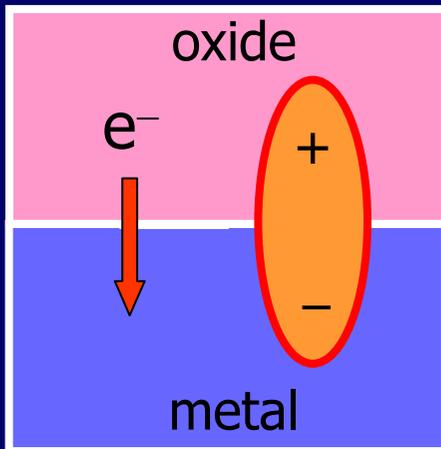
Charge transfer at the interface

No CT at the interface

oxide  $\Rightarrow$  metal CT  
BaO/Ag(100)

metal  $\Rightarrow$  oxide CT  
SiO<sub>2</sub>/Mo(112)

Pauli repulsion + polarization  
MgO/Ag(100), MgO/Mo(100)



positive dipole

negative dipole

reduced charge spillover

$$\Delta\mu > 0$$

$$\Delta\mu < 0$$

$$\Delta\mu > 0$$

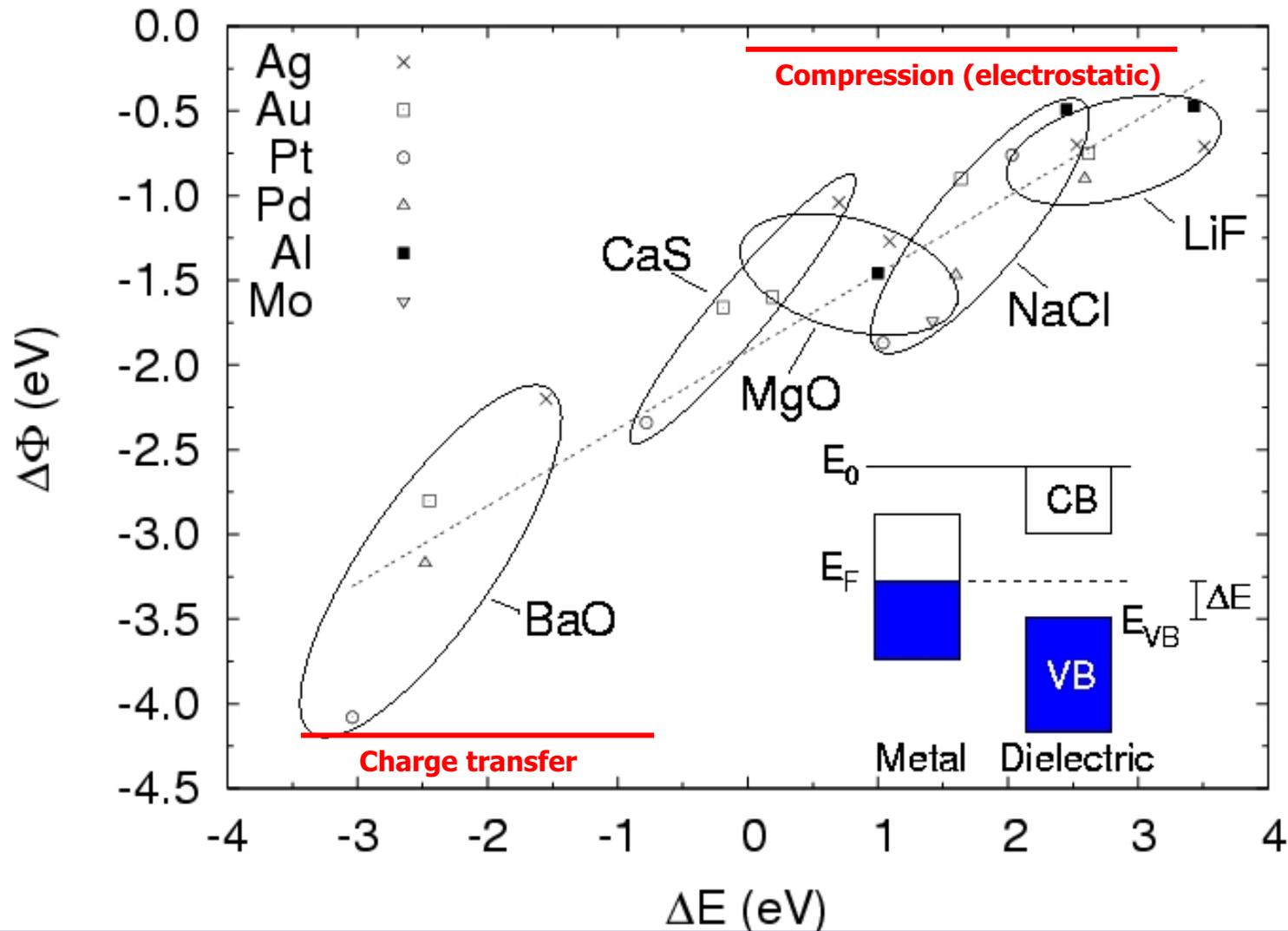
lowers  $\Phi_{\text{eff}}$

raises  $\Phi_{\text{eff}}$

lowers  $\Phi_{\text{eff}}$

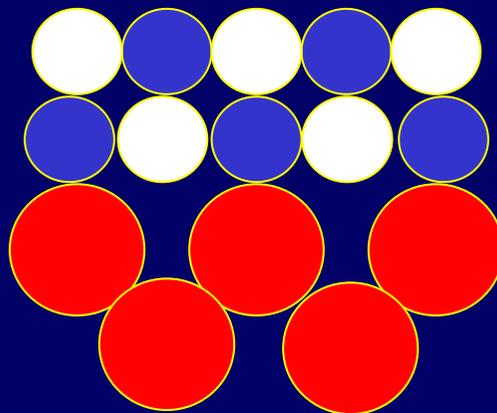
Goniakowski & Noguera, *Interf. Sci.* **12**, 93 (2004)  
Giordano, Cinquini, GP, *Phys. Rev. B* **73**, 045414 (2005)

# Factors affecting the work function change



Prada, Martinez, GP, Phys. Rev. B 78, 235423 (2008)

CAN WE TURN AN INACTIVE  
SURFACE LIKE  $\text{SiO}_2/\text{Mo}(112)$   
INTO AN ACTIVE ONE?



# MODIFY PROPERTIES OF OXIDE ULTRATHIN FILMS: DOPING

PHYSICAL REVIEW B

VOLUME 4, NUMBER 12

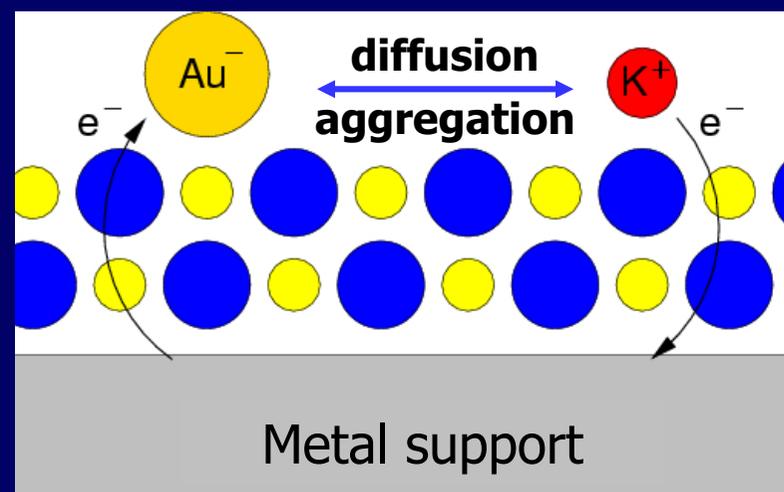
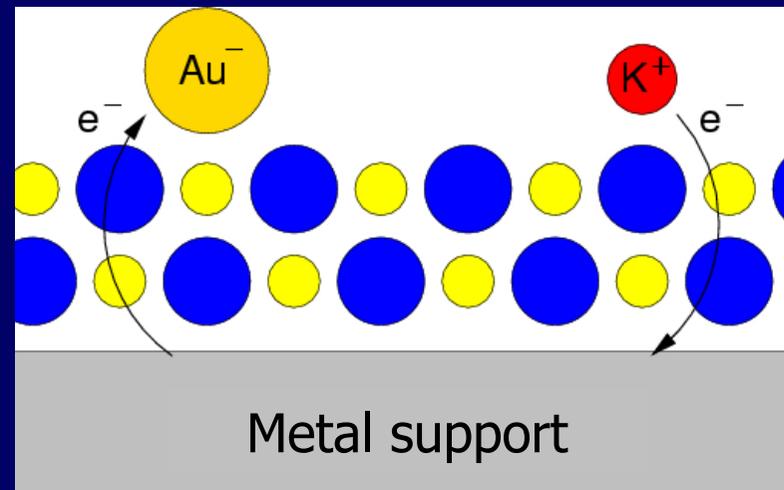
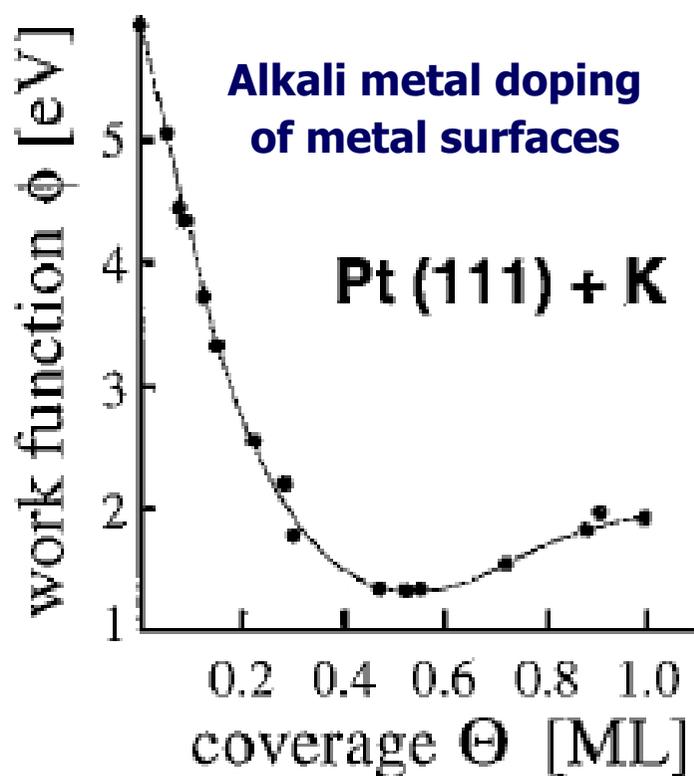
15 DECEMBER 1971

## Theory of Work-Function Changes Induced by Alkali Adsorption

N. D. Lang

IBM Thomas J. Watson Research Center, Yorktown Heights, New York 10598

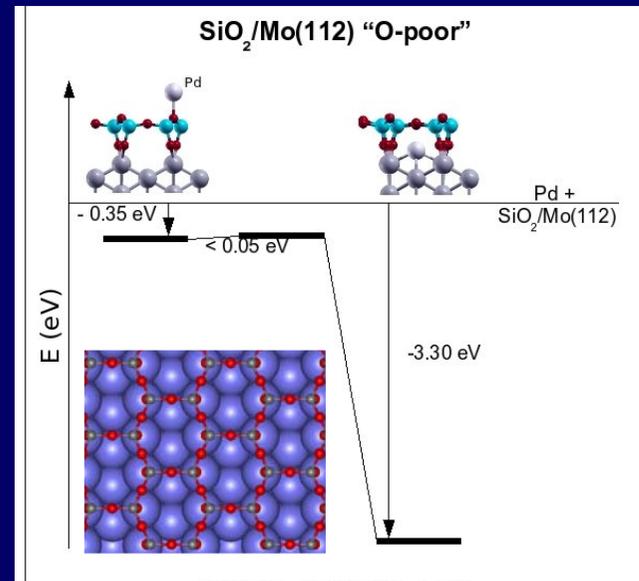
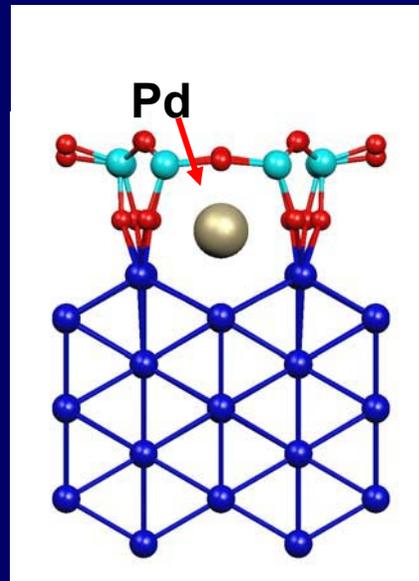
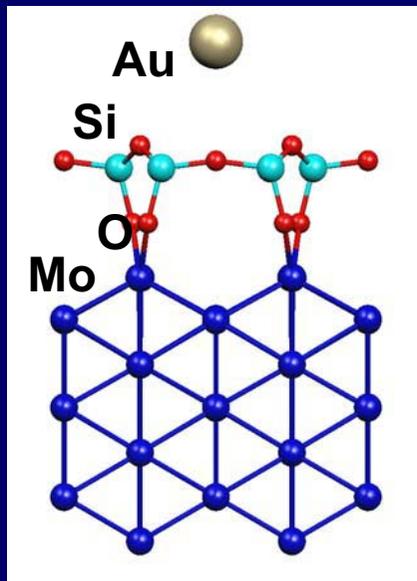
(Received 28 December 1970; revised manuscript received 19 August 1971)



# OXIDE ULTRA-THIN FILMS AS MOLECULAR SIEVES

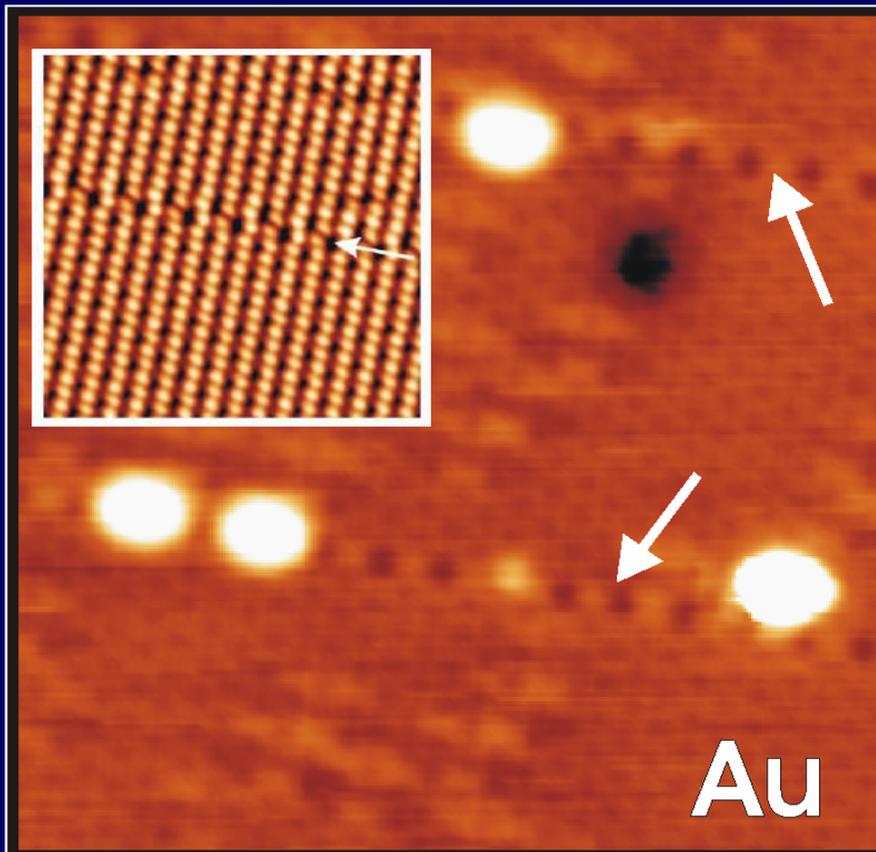
## Au and Pd adsorption: different behavior

- Au binds on the surface by 0.1 eV (easy diffusion and aggregation)
- Pd penetrates the rings & binds strongly at the interface (3.3 eV)

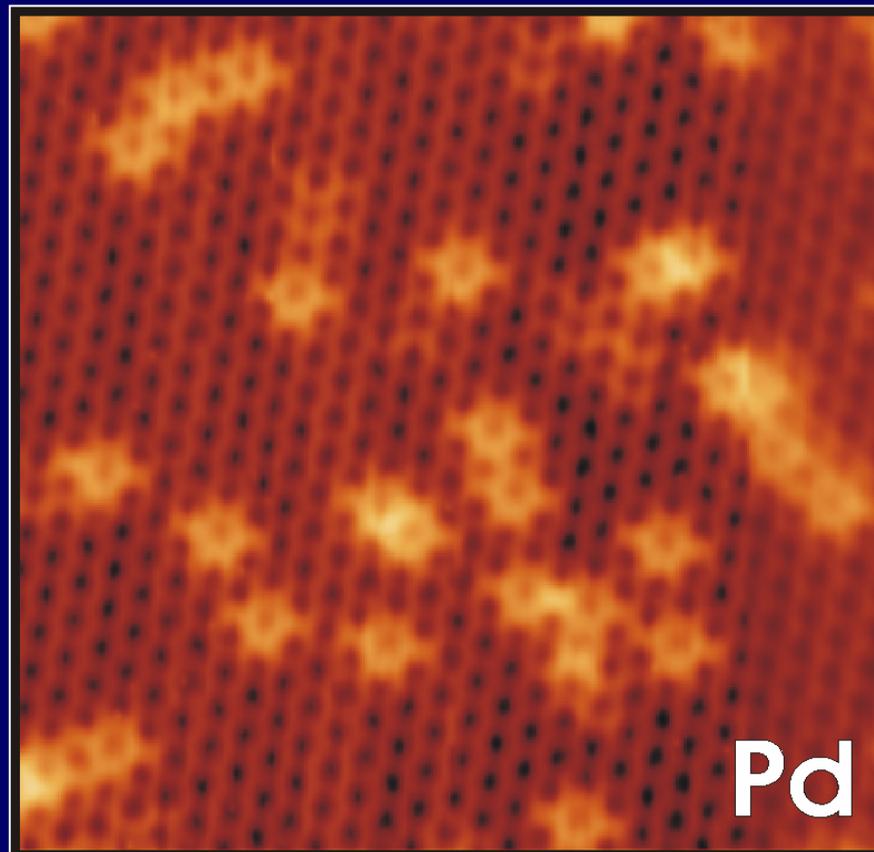


Giordano, Del Vitto, GP, J. Chem. Phys. 124, 034701 (2006)

## Au and Pd on SiO<sub>2</sub>/Mo(112): low temperature STM



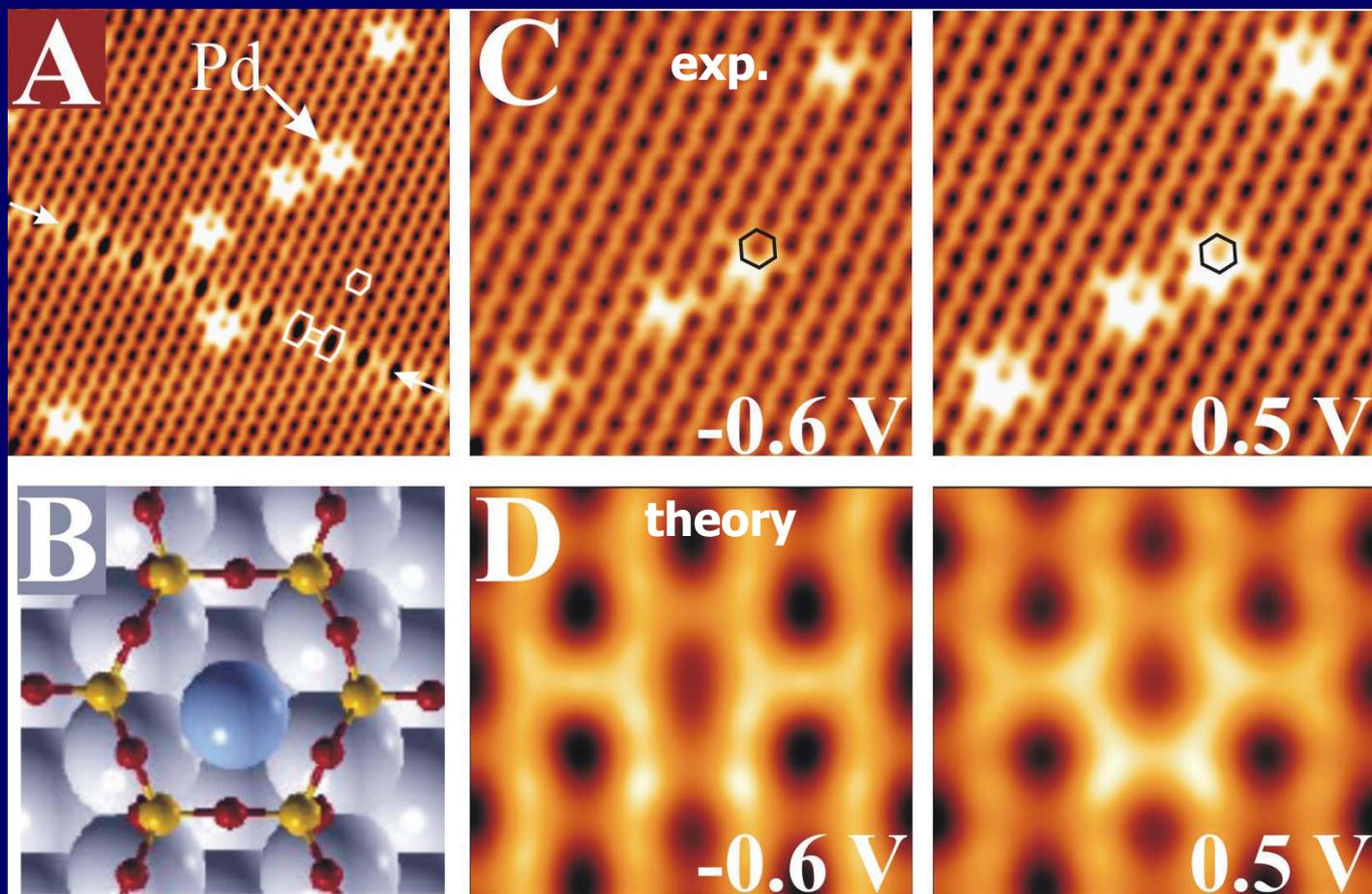
**No atoms present on the surface;  
only clusters along line defects**



**No atoms or clusters on the  
surface; only brighter ring images**

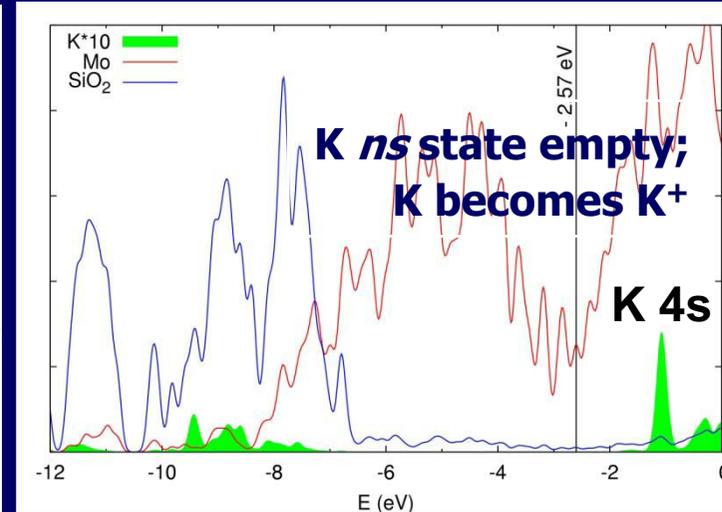
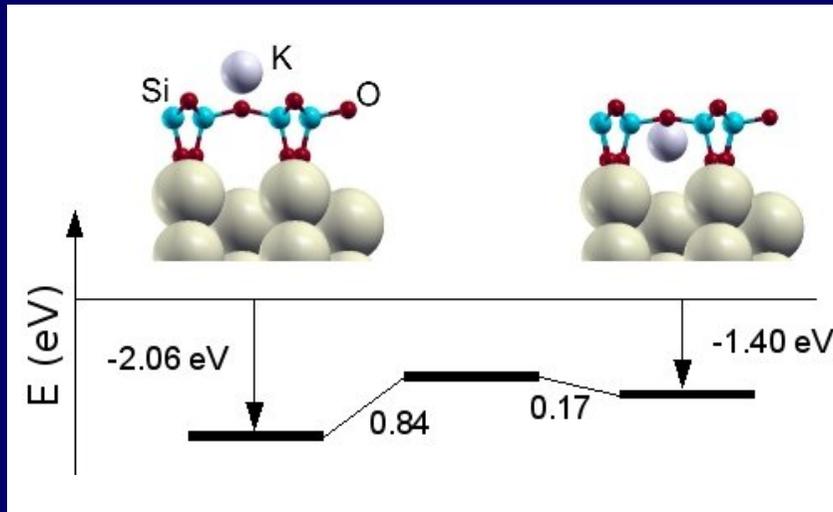
Ulrich, Nilius, Freund, Martinez, Giordano, GP, ChemPhysChem. 9, 1367 (2008)

Pd on SiO<sub>2</sub>/Mo(112): exp. and computed STM images

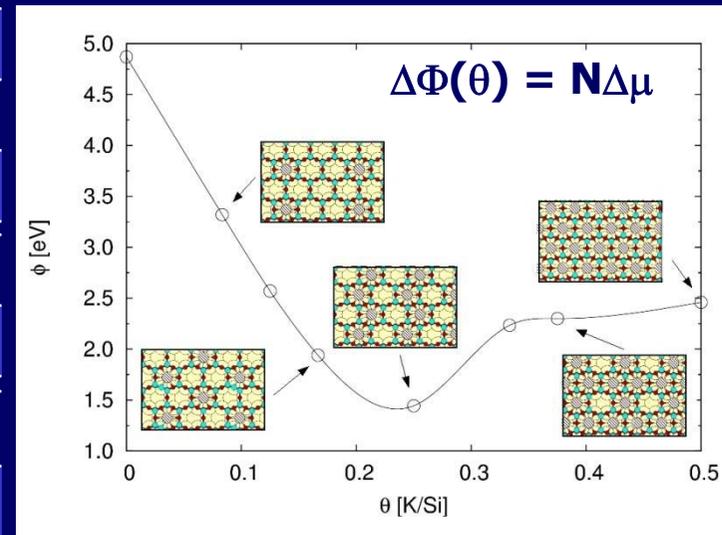


SiO<sub>2</sub>/Mo(112): two-dimensional molecular sieve

# Alkali atoms adsorption on SiO<sub>2</sub>/Mo(112): DFT



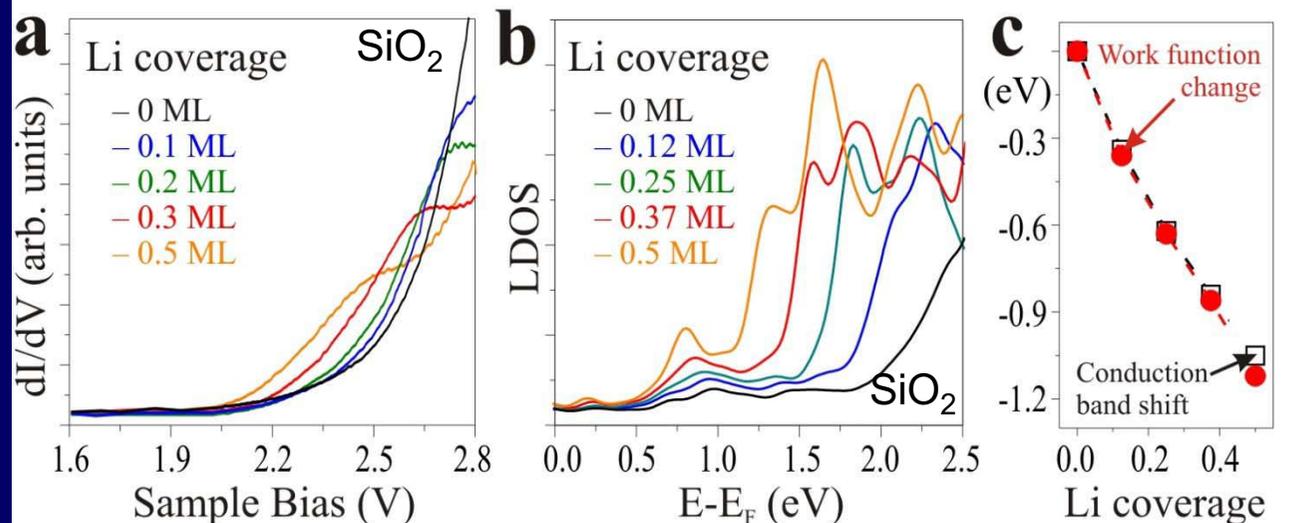
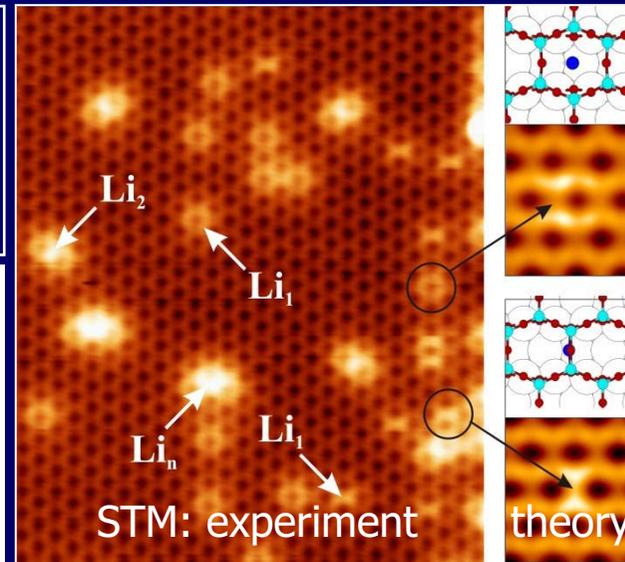
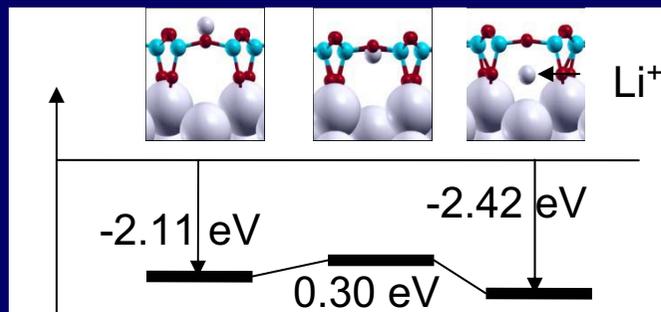
|    | Site      | $E_a$ , eV | $\Delta\Phi$ , eV |
|----|-----------|------------|-------------------|
| K  | Surface   | 2.1        | -2.3              |
|    | Interface | 1.4        | -0.6              |
| Na | Surface   | 1.8        | -1.7              |
|    | Interface | 1.7        | -0.5              |
| Li | Surface   | 2.1        | -1.5              |
|    | Interface | 2.4        | -0.4              |



Martinez, Giordano, GP, J. Chem. Phys. 128, 164707 (2008)

# Li-doped SiO<sub>2</sub>/Mo(112): STM

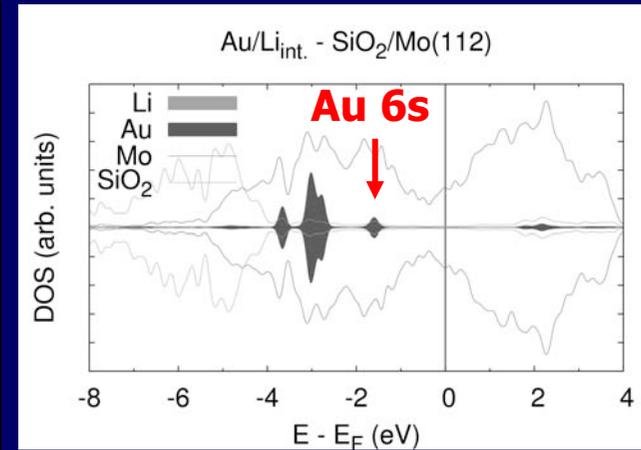
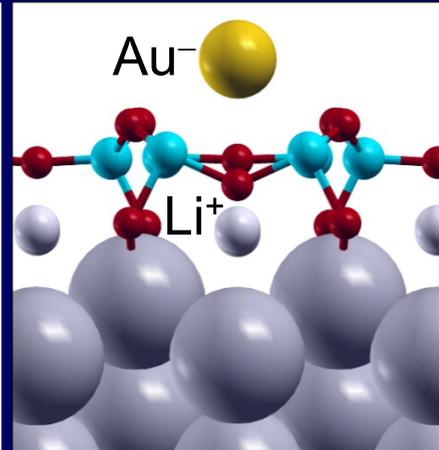
Li at interface: thermally stable  
Two adsorption sites at interface  
with same binding energy (2.4  
eV) (confirmed by STM images)



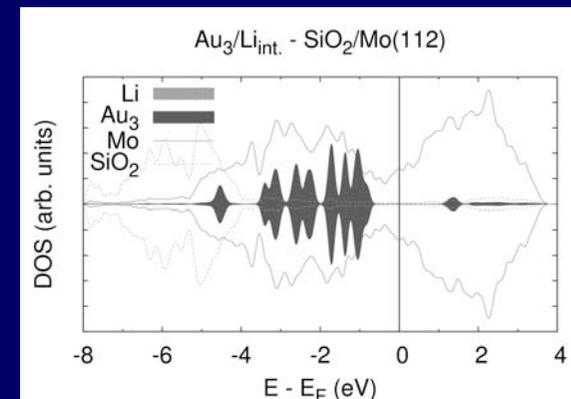
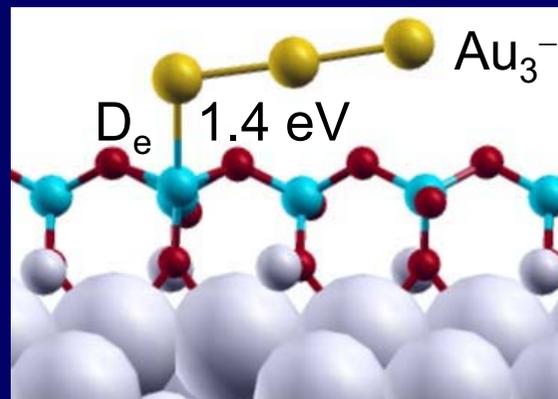
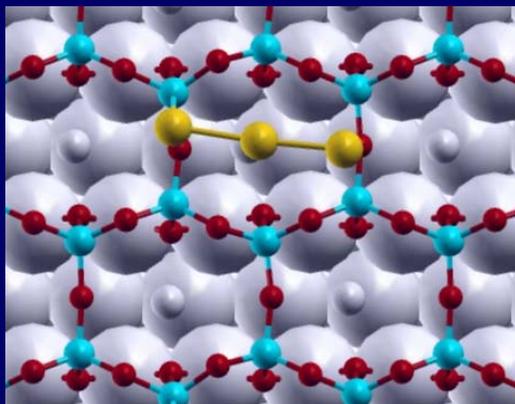
Jerratsch, Nilus, Freund, Martinez, Giordano, GP,  
Phys. Rev. B 80. 245423 (2009)

## Au atoms (and clusters) on Li-doped SiO<sub>2</sub>/Mo(112): DFT

- On Li-doped silica films **Au atom becomes Au<sup>-</sup>**
- The lattice undergoes a strong distortion (polaron)
- D<sub>e</sub> is now 1.3 eV, Au stable on silica terraces



## Au<sub>3</sub> on Li-doped silica: negatively charged



Charging induced by interface engineering!

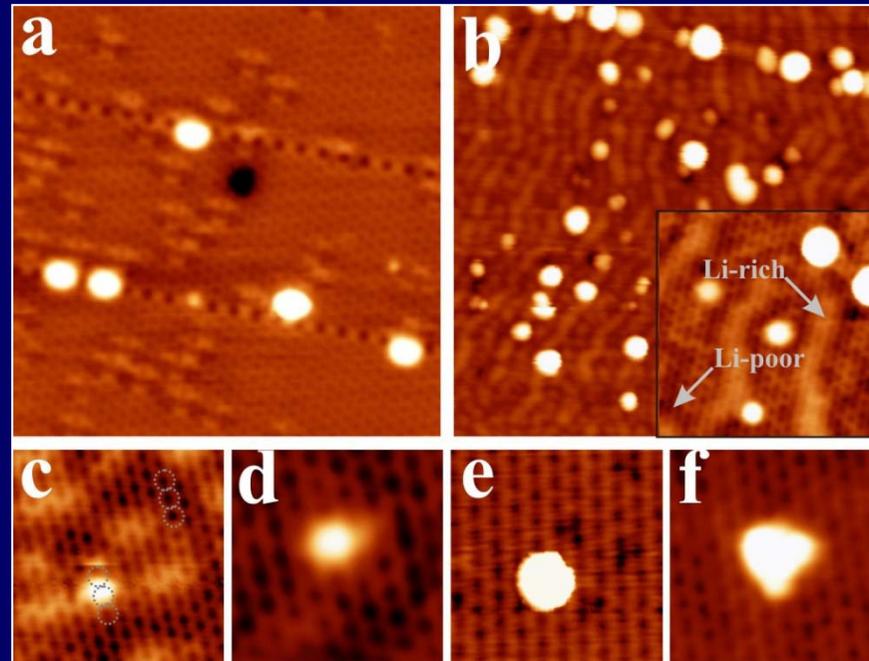
## Au atoms and clusters on Li-doped SiO<sub>2</sub>/Mo(112): STM

**(a)** SiO<sub>2</sub>: Au particles only along line defects

**(b)** Li-doped SiO<sub>2</sub>: Au clusters on defect free oxide patches

**(c)** Au monomer (on top of a bridging oxygen)

**(d, e, f)** 3D Au clusters



Surface adsorption properties modified by Li-doping

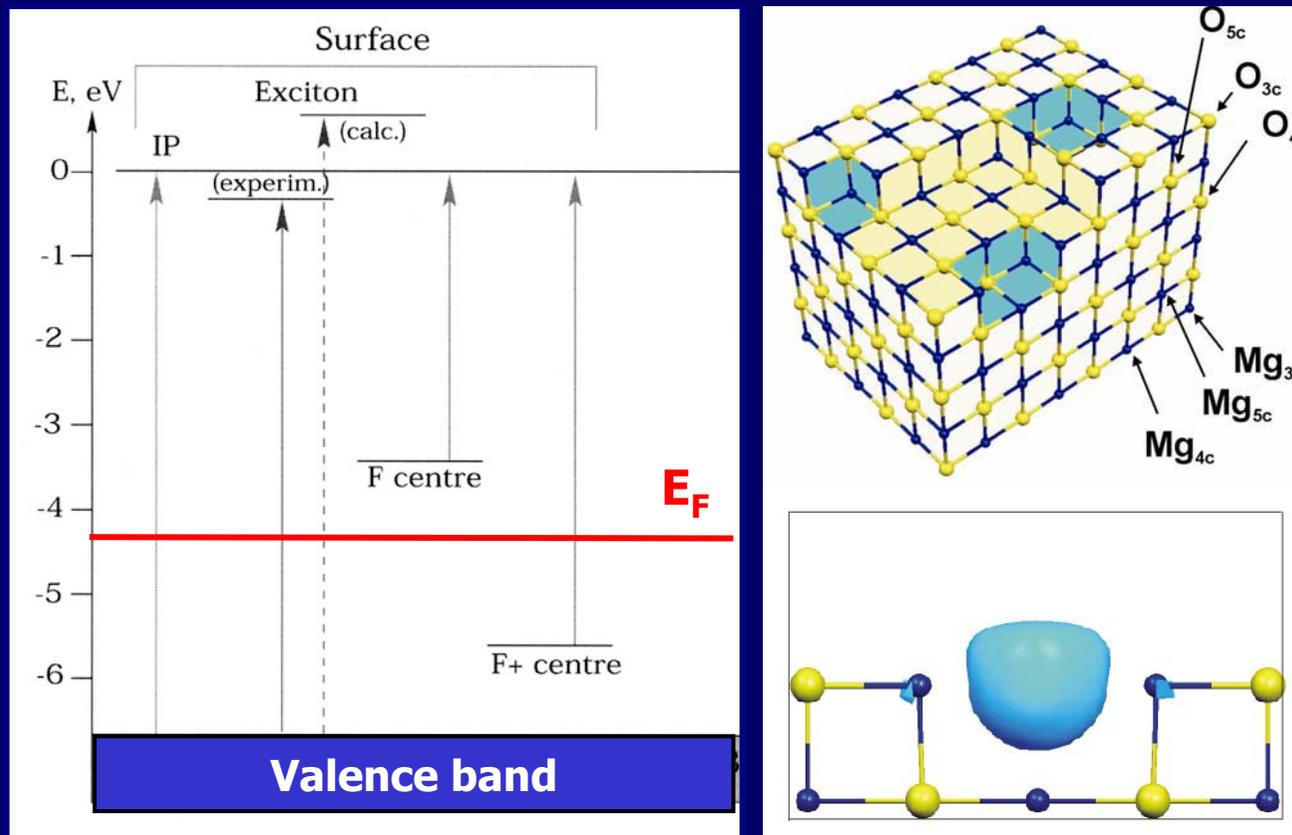
Martinez, Jerratsch, Nilius, Giordano, GP, Freund, PRL 103, 056801 (2009)

# MODIFY PROPERTIES OF OXIDE ULTRA-THIN FILMS

1) DOPING

2) DEFECTS

## O vacancies (F centers) on MgO

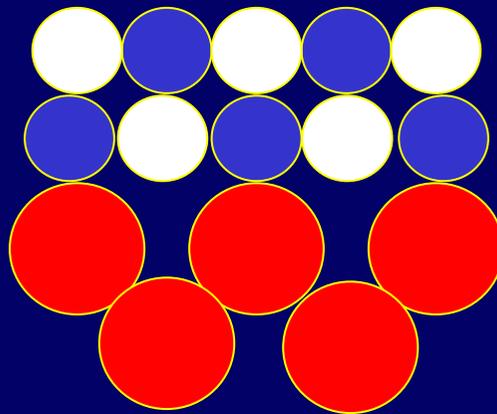


**Relative position of  $F^0$  and  $F^+$  states in MgO gap**  
Sushko, Shluger, Catlow Surf. Sci. 450, 153 (2000)

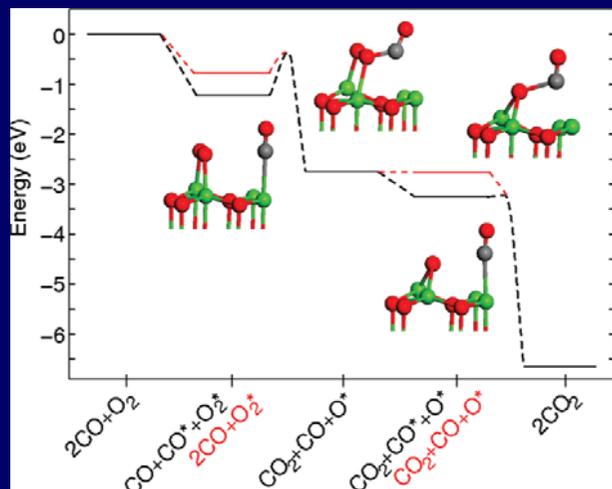
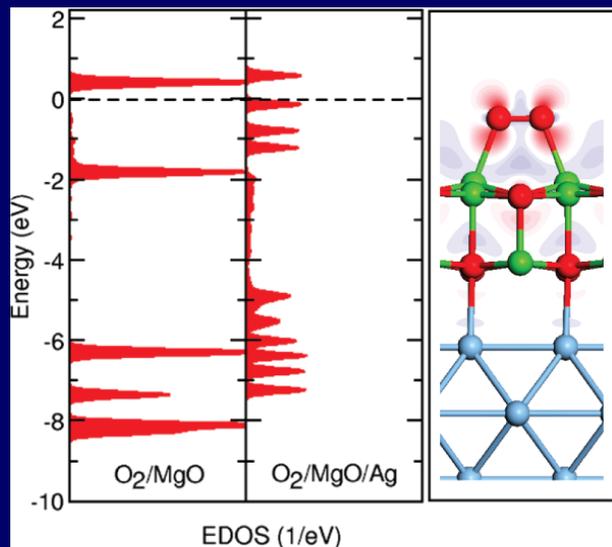
**Work function of most metals between 4 and 5 eV**

Giordano, Martinez, GP, Watkins, Shluger, J. Phys. Chem.  
C 112, 3857 (2008)

CHARGE TRANSFER THROUGH  
OXIDE ULTRATHIN FILMS:  
ONLY GOLD?



# O<sub>2</sub> ON MgO/Ag(100): FORMATION OF O<sub>2</sub><sup>-</sup> AND EASY CO OXIDATION



■ DFT shows that O<sub>2</sub> on MgO/ Ag(100) results in formation of superoxide radical anion, O<sub>2</sub><sup>-</sup>

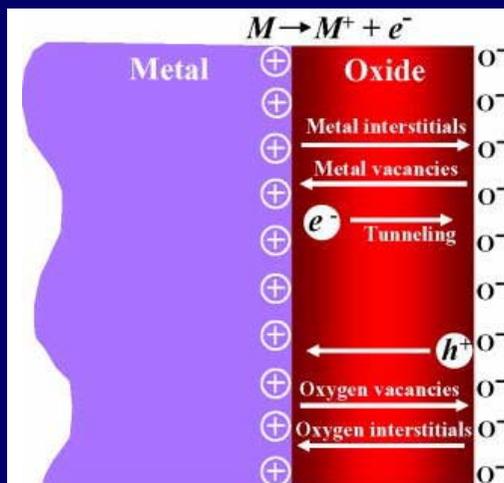
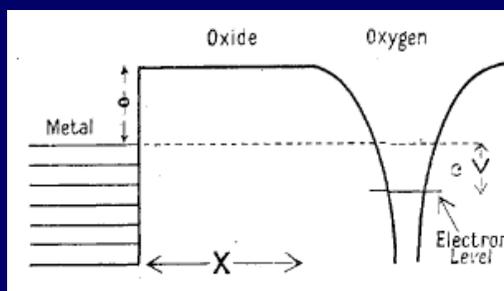
■ Subsequent reaction with CO leads to easy CO<sub>2</sub> formation

■ General mechanism for CO oxidation on metals?

Hellman, Klakar, Grönbeck J. Am. Chem. Soc, 131, 16636, 2009

## THEORY OF THE OXIDATION OF METALS

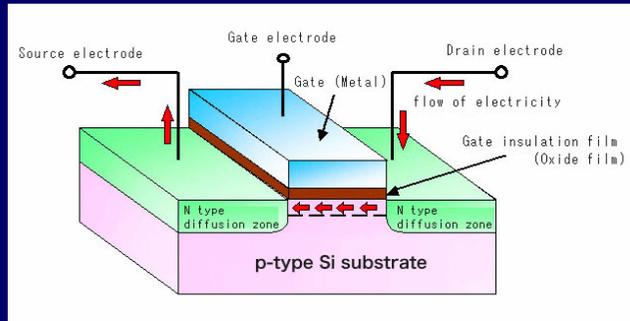
By N. CABRERA AND N. F. MOTT  
H. H. Wills Physical Laboratory, University of Bristol



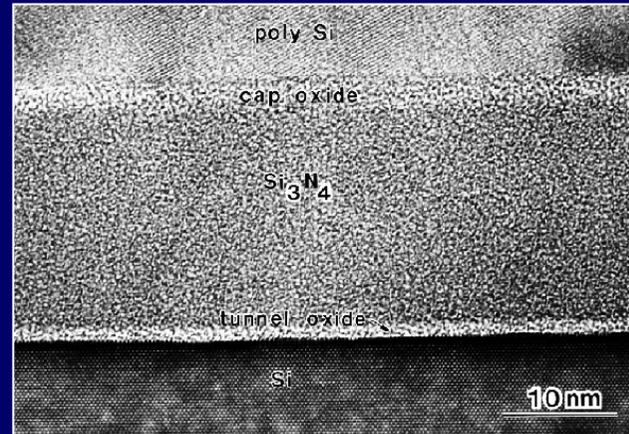
Cabrera & Mott, Rep. Progr. Phys. 2, 163, 1949

**OXIDE AND INSULATING  
ULTRATHIN FILMS: ONLY IN  
MODEL SYSTEMS?**

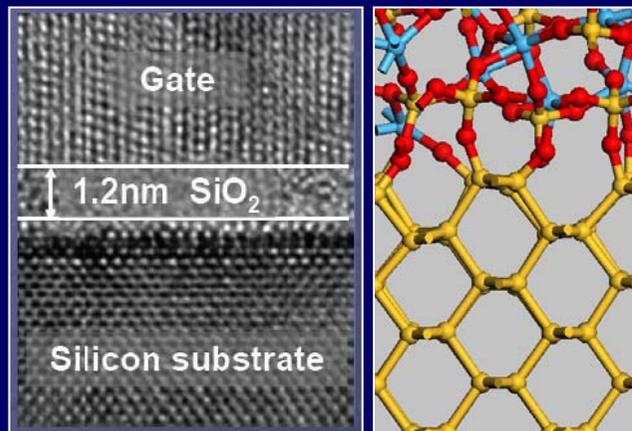
# MICROELECTRONIC DEVICES



Last generation of MOSFET:  
an ultrathin  $\text{SiO}_2$  layer  
separates gate from Si

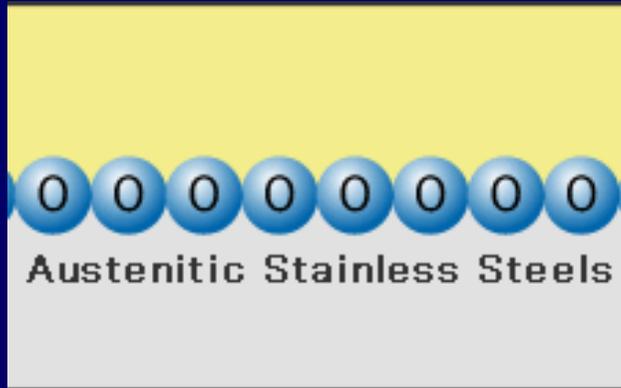


Flash memories make use  
of ultrathin oxide layers

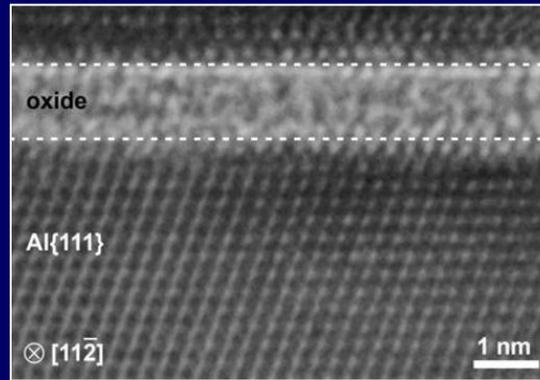




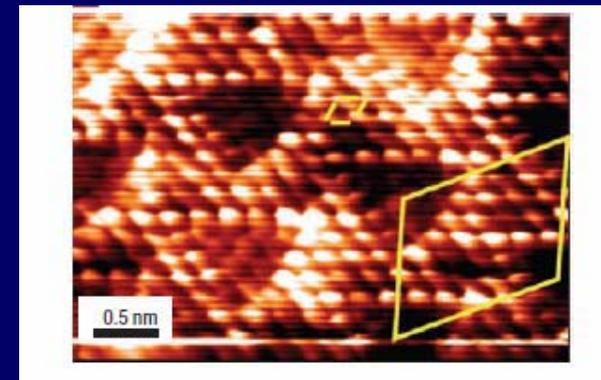
# PASSIVE FILMS ON METALS (CORROSION PROTECTION)



Outstanding corrosion resistance of stainless steel due to a thin oxide "passive" film typically 1-3 nm thick



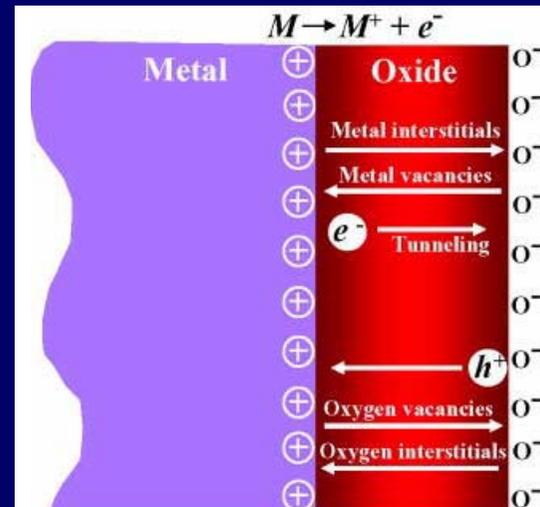
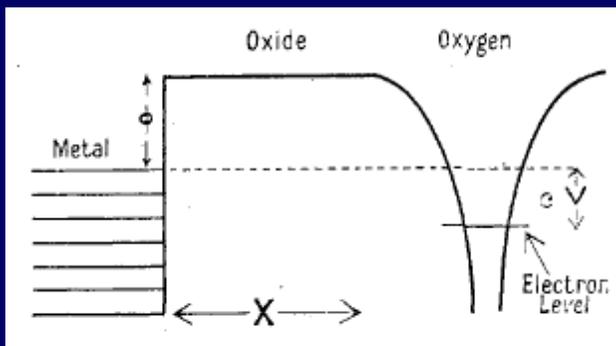
HR-TEM micrograph of an amorphous  $\text{Al}_2\text{O}_3$  oxide film grown on a bare Al(111)



STM of the TiAl(111) surface covered by a 0.6-nm-thick alumina layer [Maurice et al. Nat. Mater. 3, 687 (2004)]

## THEORY OF THE OXIDATION OF METALS

BY N. CABRERA AND N. F. MOTT  
H. H. Wills Physical Laboratory, University of Bristol

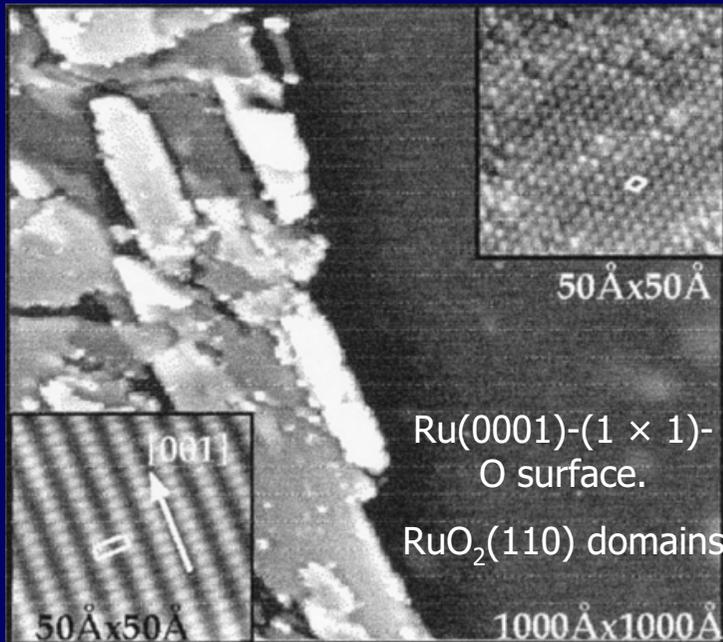
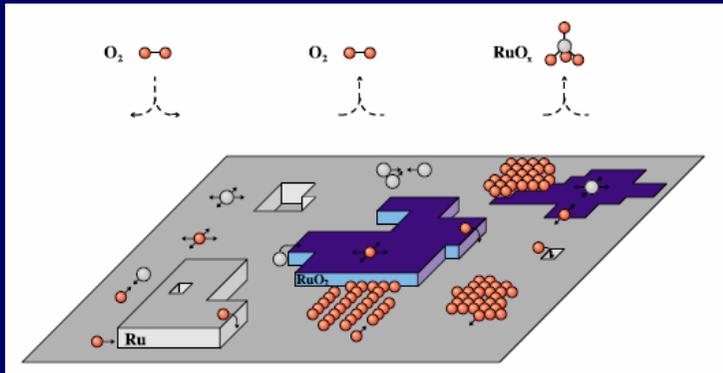


**Cabrera, Mott, Rep. Progr. Physics (1949)**

**Olsson, Landolt, Electrochim. Acta 48, 1093 (2003)**

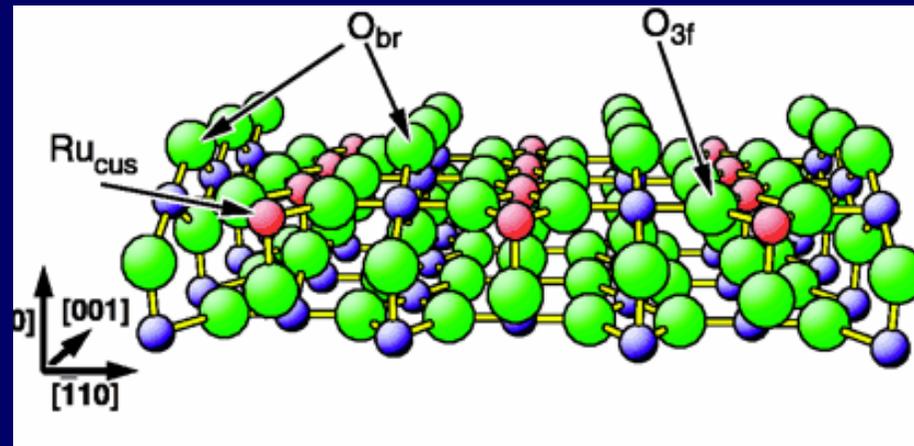
**Schultze, Lohrengel, Electrochim. Acta 45, 2499 (2000)**

# OXIDE FILMS: RELEVANT FOR CATALYSIS BY METALS?

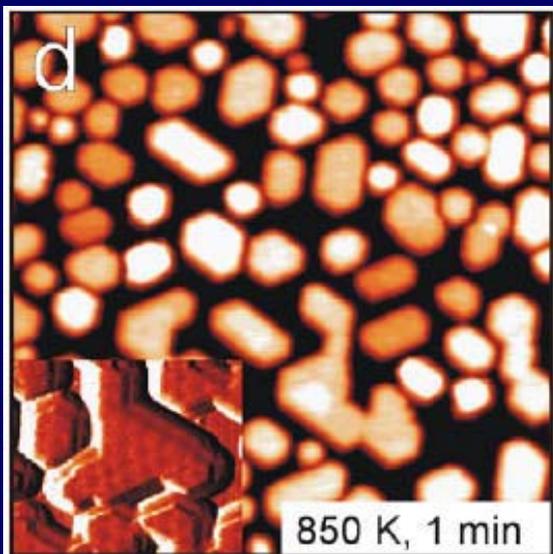


Ru metal in UHV is practically inactive in CO oxidation; it becomes very active at atmospheric pressure. Active phase under high  $O_2$  exposures on Ru(0001) is a thin overlayer of  $RuO_2(110)$

Over, Kim, Seitsonen, Wendt, Lundgren, Schmid, Varga, Morgante, Ertl, *Science* **2000**, 287, 1474

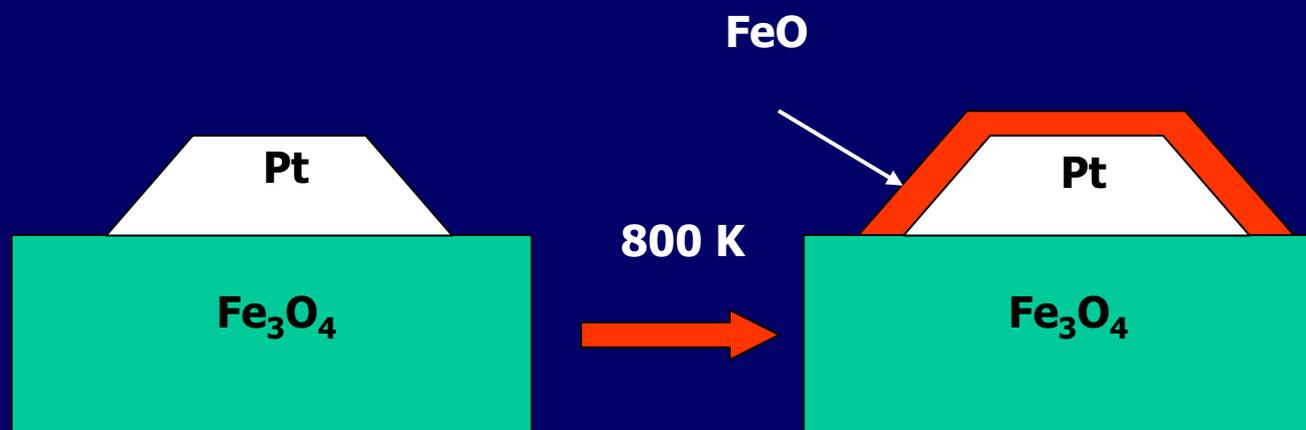


## STRONG METAL SUPPORT INTERACTION (SMSI) IN CATALYSIS BY SUPPORTED METAL PARTICLES

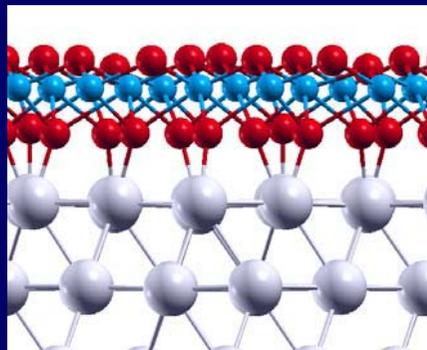
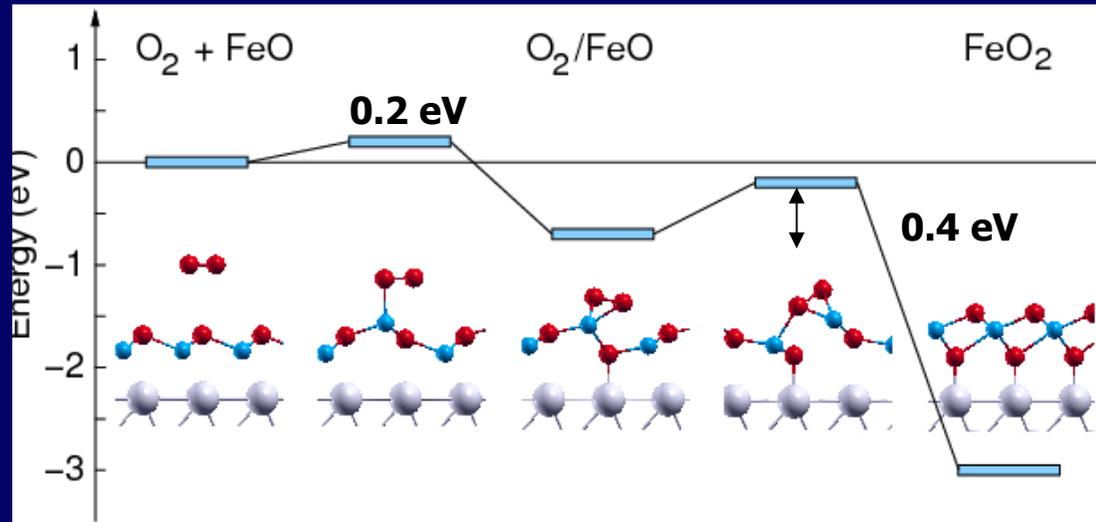


- SMSI: encapsulation of metal particles on oxides by a thin oxide film
- Usually results in reduced activity
- Recently examples have been reported of increased activity in CO oxidation
- Pt on  $\text{Fe}_3\text{O}_4$ : the encapsulating layer has the FeO/Pt(111) structure

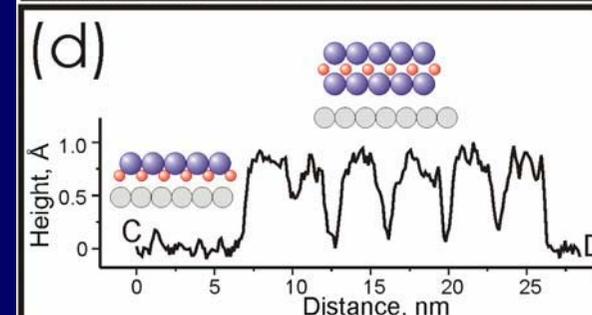
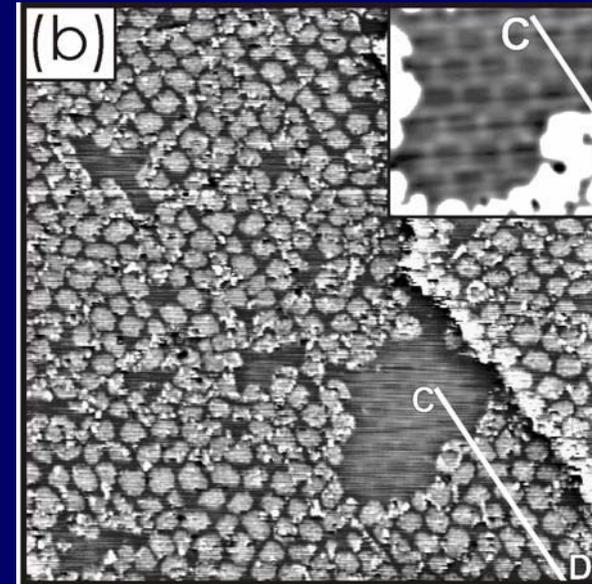
Shaikhutdinov, Freund, et al. *J. Catal.* **2009**, 266, 359



# O<sub>2</sub> DISSOCIATION ON FeO/Pt(111)

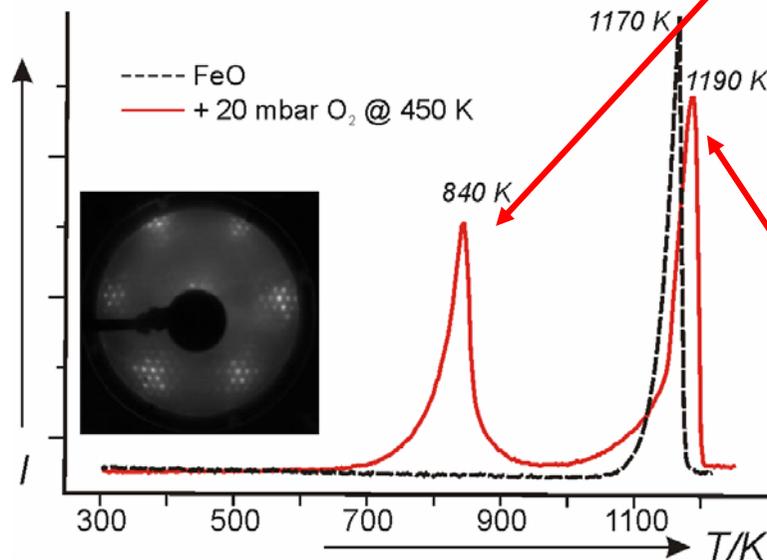
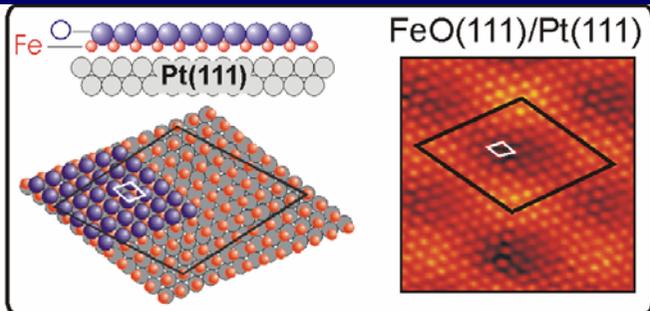


- O<sub>2</sub><sup>2-</sup> peroxy species dissociates overcoming a barrier of ~ 0.4 eV
- A new FeO<sub>2</sub> phase forms (also from STM)

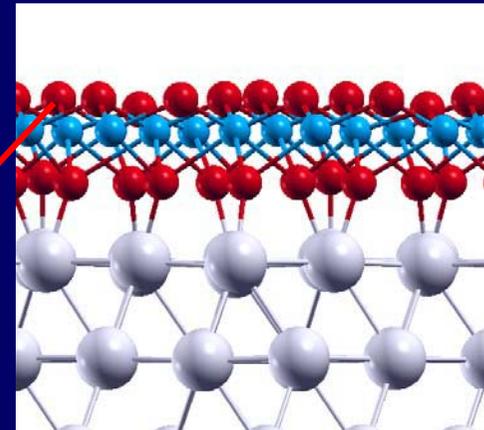


**Exposure of FeO/Pt(111) films to O<sub>2</sub> pressure leads to a FeO<sub>2</sub> film with an O-Fe-O trilayer structure**

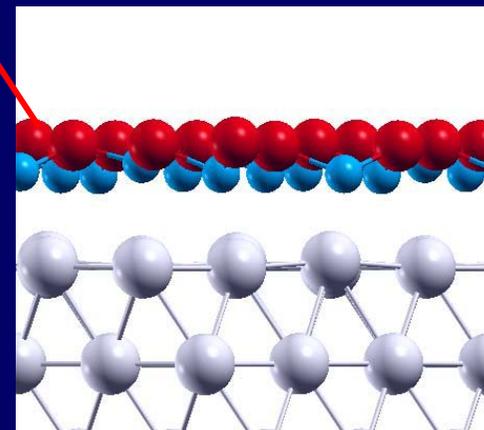
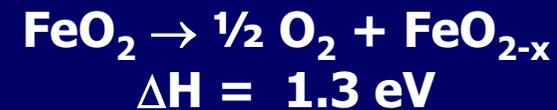
# FeO/Pt(111) VERSUS FeO<sub>2</sub>/Pt(111)



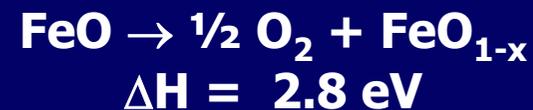
- FeO<sub>2</sub>: two O<sub>2</sub> desorption peaks at 840 K and 1190 K
- Consistent with DFT calculations showing easier O desorption from FeO<sub>2</sub> than from FeO top layer



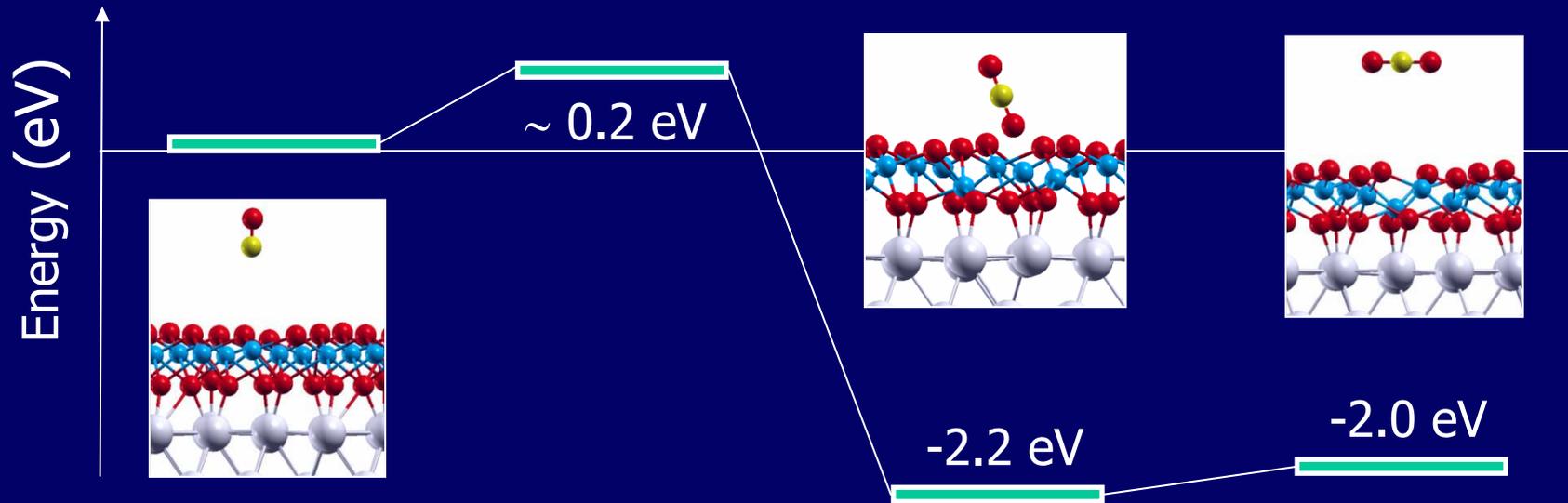
0.29 e<sup>-</sup>



0.23 e<sup>-</sup>



## CO ADSORPTION AND OXIDATION ON FeO<sub>2</sub>/Pt(111)



$\text{CO} + \text{FeO}_2 \rightarrow \text{CO}_2 + \text{FeO}_{2-x}$       $\Delta H = -2.0 \text{ eV}$   
High energy gain related to low cost of vacancy formation (1.3 eV)

- **Small vacancy formation energy, FeO<sub>2</sub>/Pt(111) film promotes CO oxidation**
- **Ambient O<sub>2</sub> restores the O content of the film. Reaction follows a classical Mars-Von Krevelen mechanism**

Giordano, Goniakowski, Shaikutdinov, GP, Freund et al. Angew. Chem. (2010)

## SOME CONCLUSIONS

■ Ultrathin oxide films **may** behave differently from bulk oxides (new phases, properties connected to the reduced dimensionality, structural flexibility and easy reconstruction)

■ Charging of supported atoms & clusters (and molecules) occurs by tunneling through the thin dielectric layer

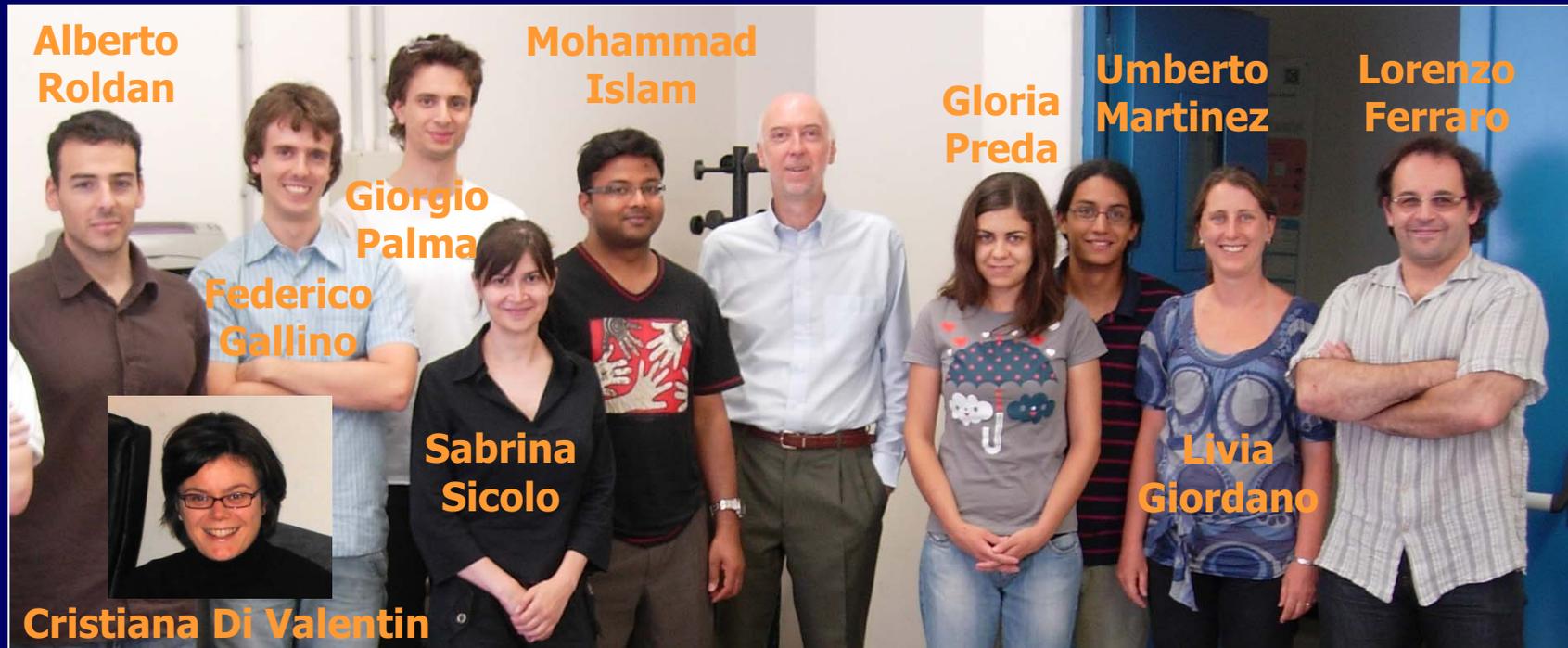
■ Charge transfer depends on (a) electron affinity of adsorbates, (b) work function of oxide/metal interface, (c) possibility for the oxide film to undergo polaronic distortion, (d) film thickness

■ Engineering of metal/oxide interfaces:

- alkali metal adsorption
- selected defects (not shown)
- multilayer growth (not shown)

■ Consequences:

- enhanced cluster reactivity
- enhanced surface reactivity



**HJ Freund**



**M Heyde**



**N Nilius**



**J Goniakowski**  
**Université Paris VI**



**T Risse**



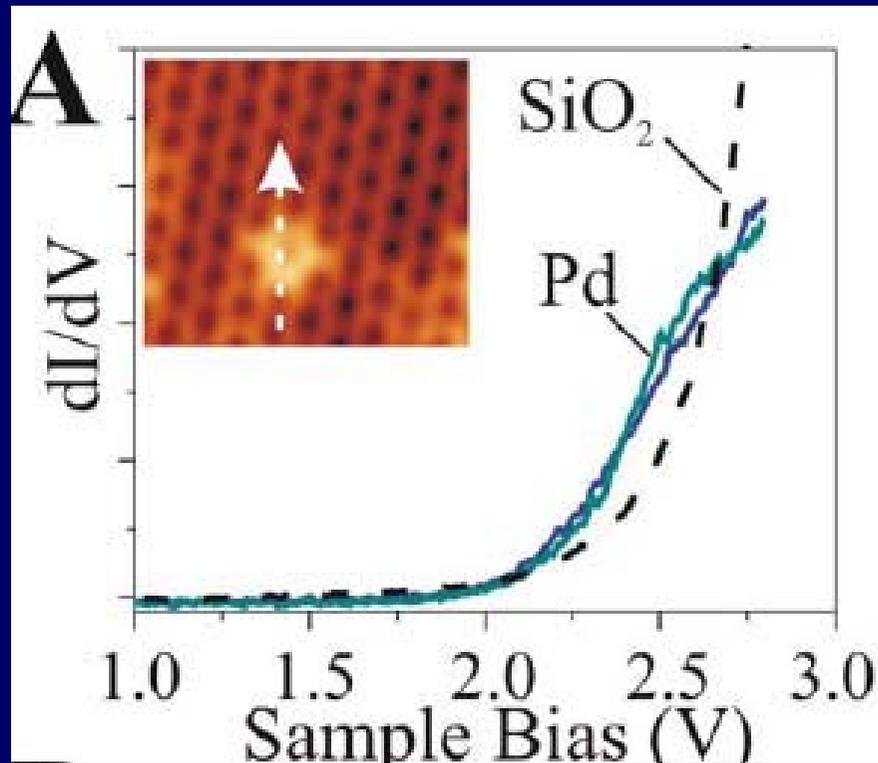
**M Sterrer**



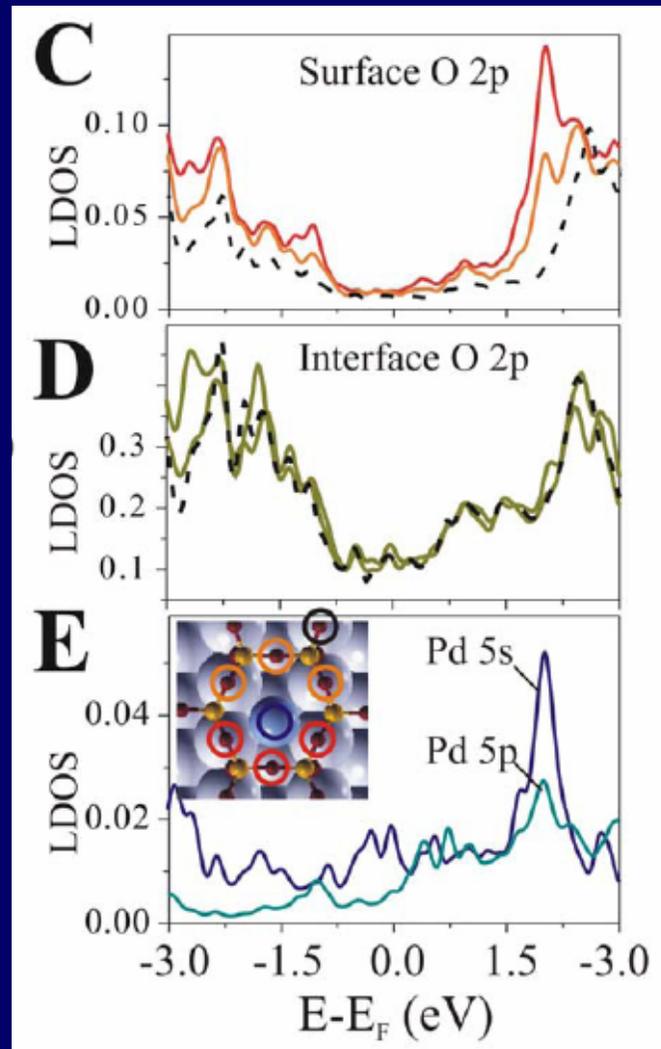
**Shaikutdinov**

**Support: Barcelona  
Supercomputing Center  
– CILEA Computing  
Center – Univ. Milano  
Bicocca – COST D41**

## Pd on SiO<sub>2</sub>/Mo(112): measured and experimental images



- Enhanced brightness of silica ring due to hybridization of O  $2p$  states with Pd  $5s$  empty state (see DOS)
- Consistent with  $dI/dV$  curves



# CHARGE TRANSFER THROUGH THIN FILMS: NO<sub>2</sub>/MgO/Ag(100)

*J. Phys. Chem. B* 2006, 110, 11977–11981

11977

Mechanism for NO<sub>2</sub> Charging on Metal Supported MgO

Henrik Grönbeck\*

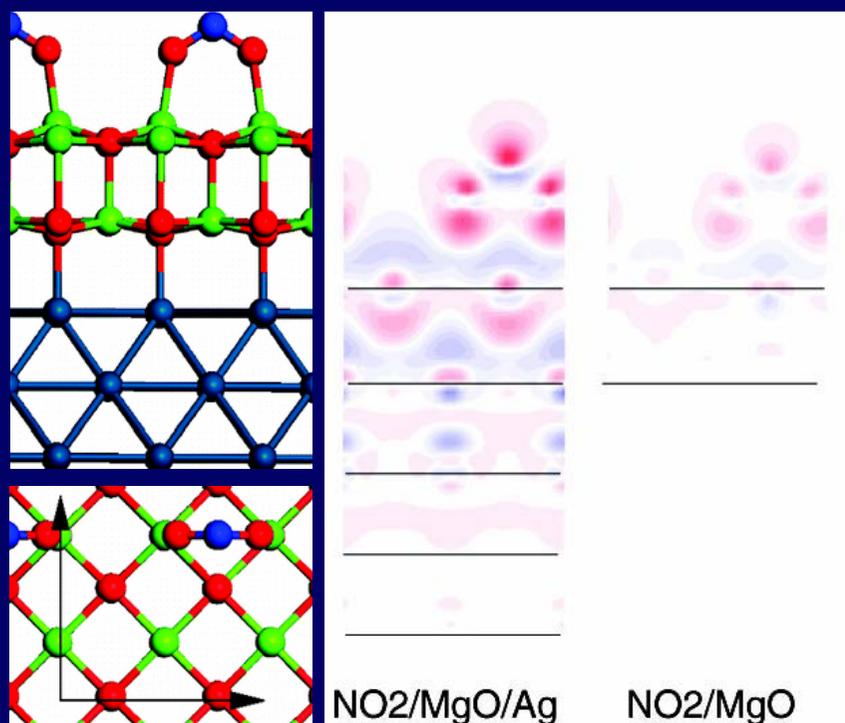
Competence Centre for Catalysis and Department of Applied Physics, Chalmers University of Technology, SE-412 96 Göteborg, Sweden

*J. Phys. Chem. C* 2009, 113, 7355–7363

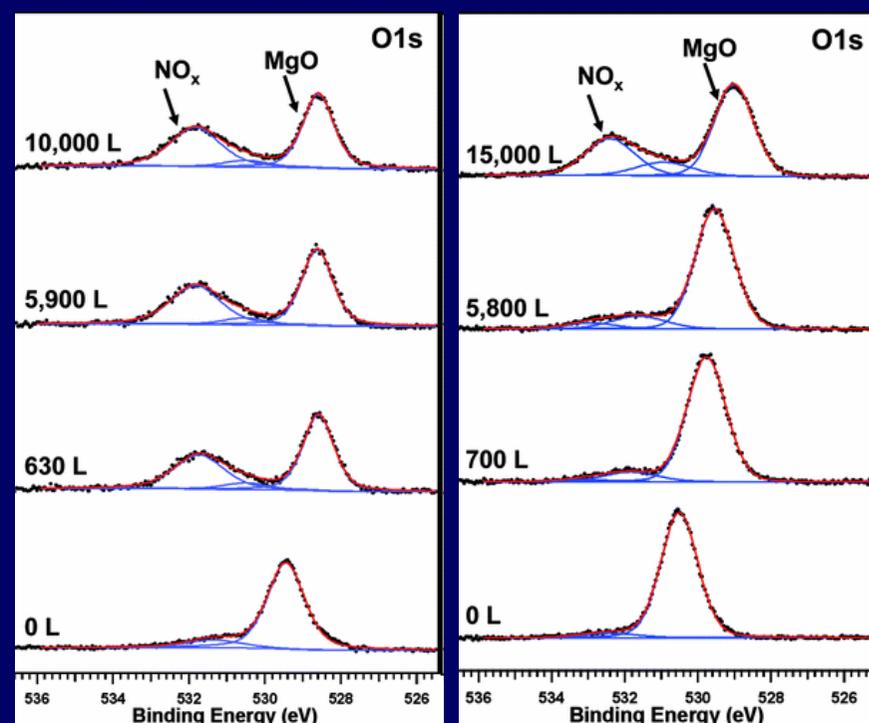
7355

NO<sub>2</sub> Adsorption on Ag(100) Supported MgO(100) Thin Films: Controlling the Adsorption State with Film Thickness

David E. Starr,<sup>1,7</sup> Christoph Weis,<sup>7,8</sup> Susumu Yamamoto,<sup>8</sup> Anders Nilsson,<sup>11</sup> and Hendrik Bluhm<sup>\*,7</sup>



Charge density difference for NO<sub>2</sub> adsorbed on a 2 ML thick MgO/Ag(100) and on bare MgO. The plot shows accumulation of charge on the thin film



O 1s spectra for increasing NO<sub>2</sub> exposure to a 2 ML thick MgO/Ag(100) film

O 1s spectra for increasing NO<sub>2</sub> exposure to a 8 ML thick MgO/Ag(100) film

# Possible effects on catalysis

- $Au_n$  on a thin film: **2D**

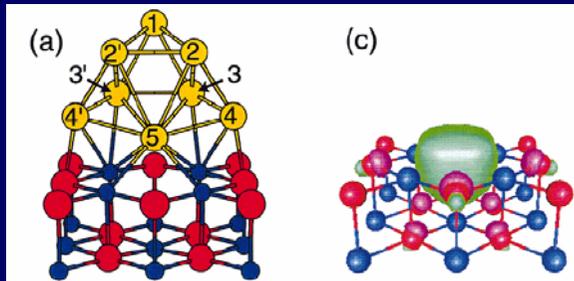
- larger periphery

- extra charge, more active

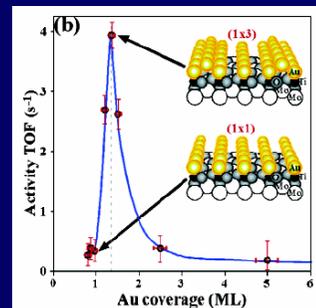
- $Au_n$  on a thick film: **3D**

- smaller periphery

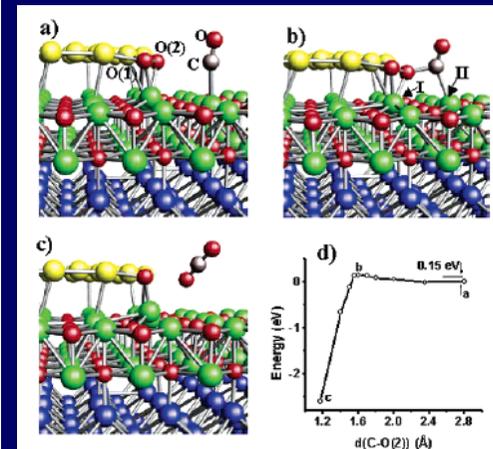
- neutrals, less active



Charged  $Au_8/MgO$  cluster on F center more active than same cluster on non-defective MgO (Sanchez, Heiz, Landman et al. JPC A 103, 9573, 1999)

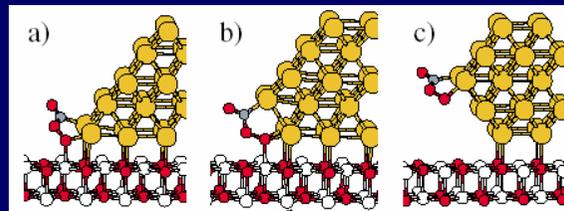


$Au/TiO_x/Mo$ : Au 2L much more active than 3L-5L of Au (Chen, Goodman, Acc. Chem. Res. 39, 739, 2006)

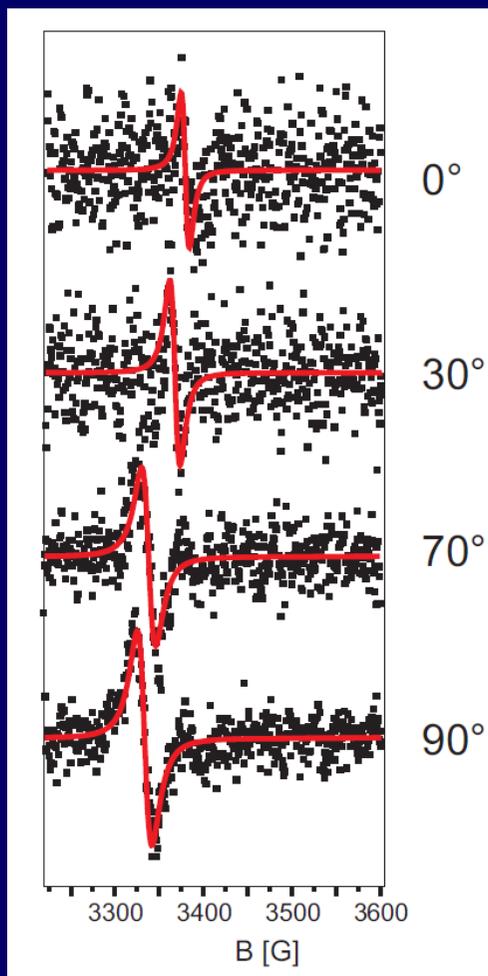


$Au_{20}/MgO/Mo$ :  $Au_{20}$  2D more active than  $Au_{20}$  3D in CO oxidation (Zhang, Yoon, Landman J. Am. Chem. Soc. 129, 2228, 2007)

Au cluster on MgO: periphery more active (Molina, Hammer, PRL 90, 206102, 2006)



# FORMATION OF $O_2^-$ ON MgO/Ag(100): PROOFS FROM EPR

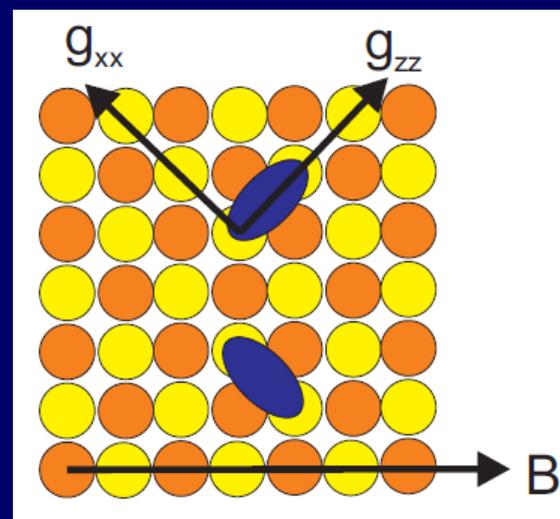


Fit-Parameter

$$g_{xx} = 2.004(5)$$

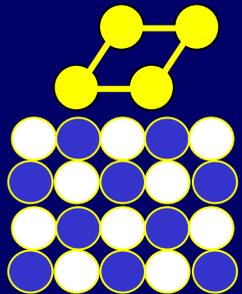
$$g_{yy} = 2.015$$

$$g_{zz} = 2.072$$

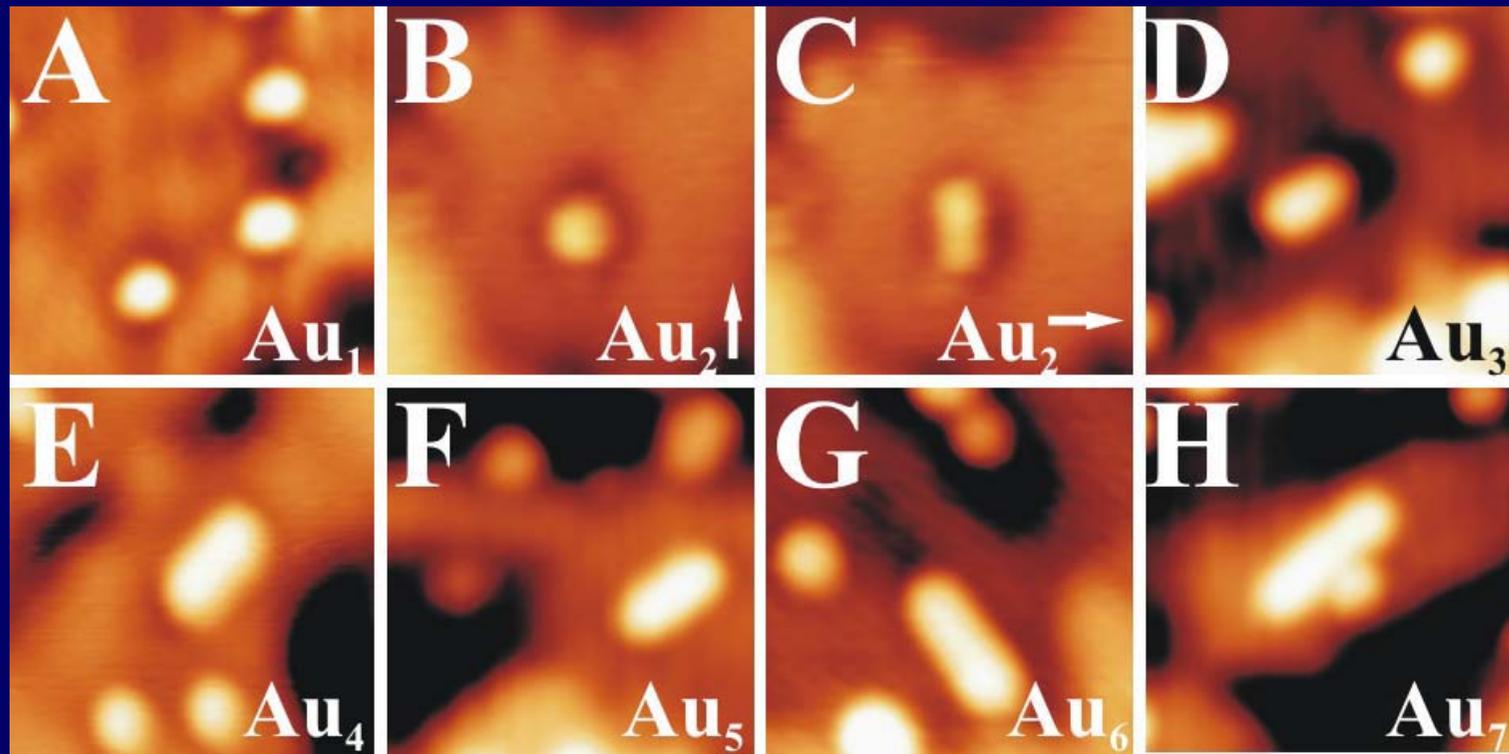
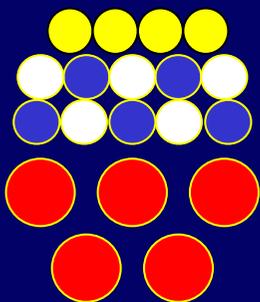


## Small Au clusters on MgO/Ag(100)

MgO(100)



MgO/Ag



**Structure of small gold clusters different on MgO(100) and MgO/Ag(100)**

Simic-Milosevic, Heyde, Lin, König, Rust, Sterrer, Risse,  
Nilius, Freund, Giordano, GP, Phys. Rev. B, 78, 235429 (2008)  
Frondelius, Hakkinen, Honkala, Phys. Rev. B 76, 073406 (2007)